

International Conference on Ultrafast Optical Science

September 30-October 04, 2019

Lebedev Physical Institute of RAS

**Femtosecond laser 3D  
micromachining: from research  
prototype to industrial tool**

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East China Normal University



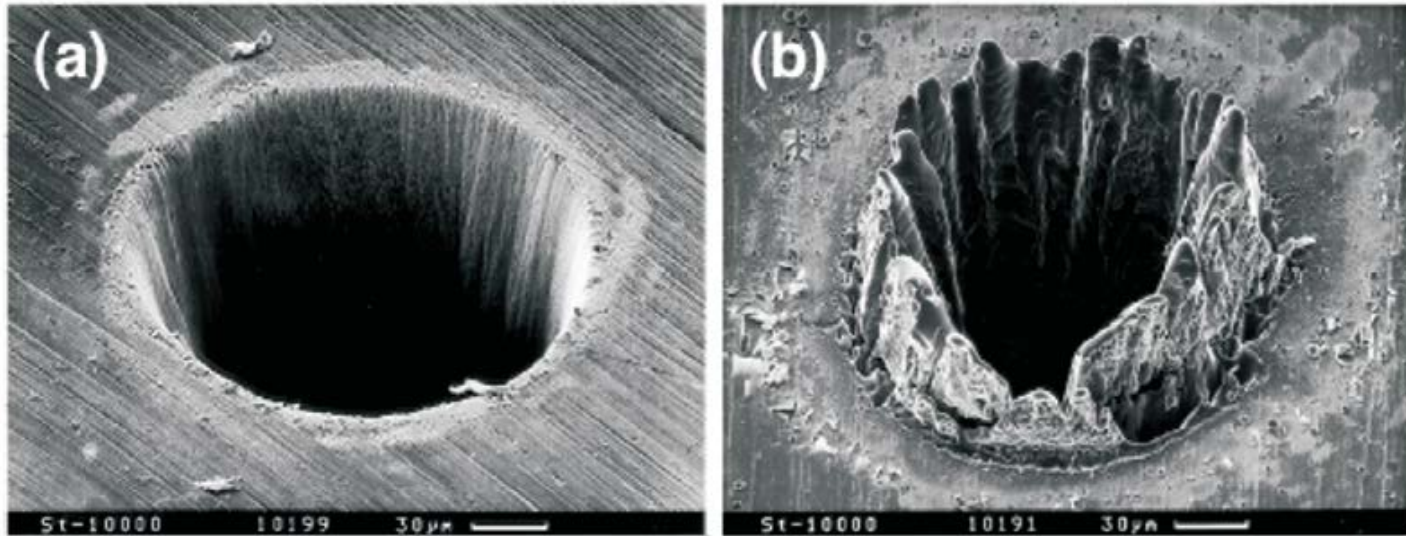
**XXL - THE EXTREME OPTOELECTROMECHANIX LAB**

**Why femtosecond laser  
for micromachining?**

# I. Ultrashort pulse width: suppress thermal effects

**Femtosecond**

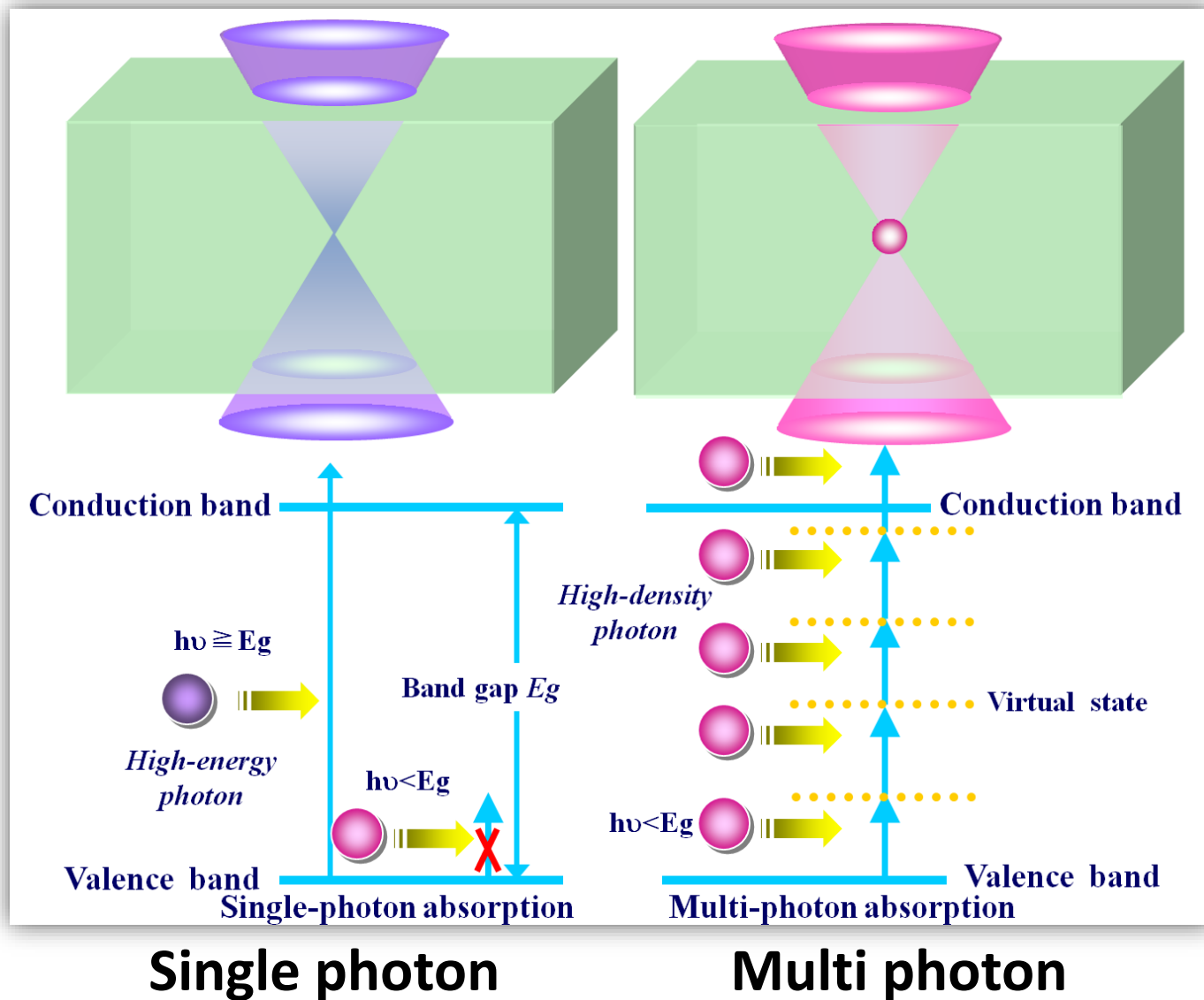
**Nanosecond**



**Figure 1.4** Holes drilled in 100  $\mu\text{m}$ -thick steel foils by ablation using laser pulses with the following parameters: (a) pulse width: 200 fs, pulse energy: 120  $\mu\text{J}$ , fluence: 0.5  $\text{J}/\text{cm}^2$ , wavelength: 780 nm; and (b) pulse width: 3.3 ns, pulse energy: 1 mJ, fluence: 4.2  $\text{J}/\text{cm}^2$ , wavelength: 780 nm. The scale bars represent 30  $\mu\text{m}$ . Courtesy of A. Ostendorf.

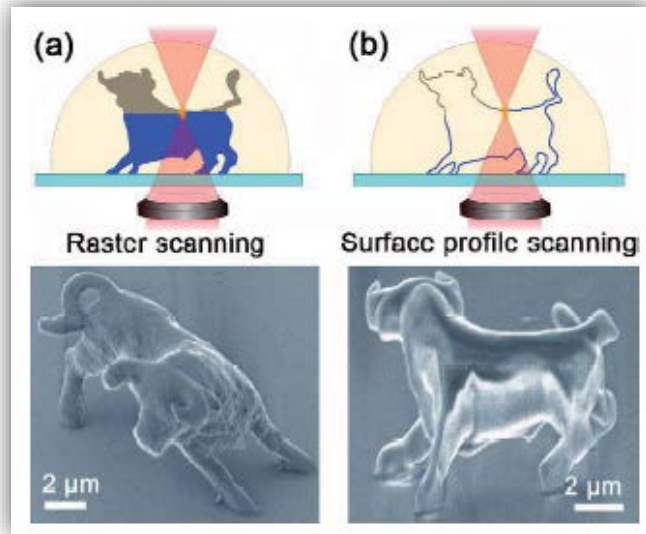
*B. N. Chichkov, et al., Appl. Phys. A 63, 109 (1996)*

## II. Ultrahigh intensity: 3D internal processing



# III. Ultrahigh nonlinearity: break diffraction limit

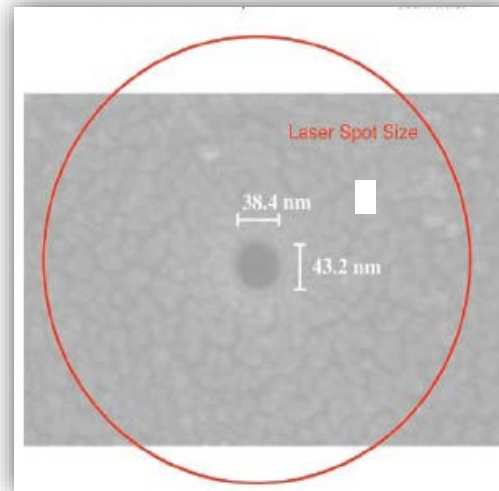
## Two-photon polymerization



*S. Kawata, et al., Nature 412, 697(2001)*

Resolution: ~ 100 nm

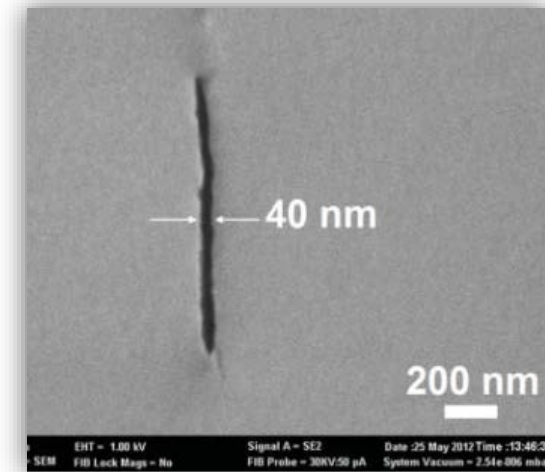
## Surface ablation of glass



*A. P. Joglekar, et al., PNAS 101, 5856(2004)*

Resolution: ~ 40 nm

## In-volume direct writing in glass



*Y. Liao, et al., Lab Chip 13, 1626 (2013)*

Resolution: ~ 40 nm

**Nonlinear threshold effect provides a resolution far beyond that allowed by the diffraction limit**

# Challenges toward industrial scale applications

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To bring femtosecond laser 3D micromachining to the commercial market, we need:

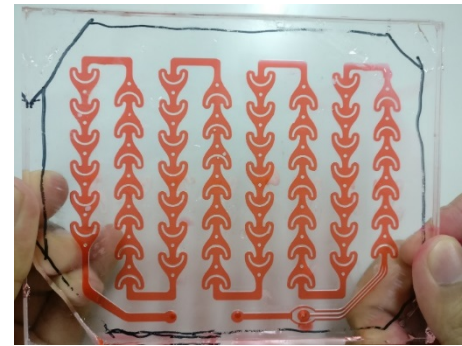
1. High fabrication efficiency;
2. Large workpiece size;
3. Broad materials coverage !

# Today's topics

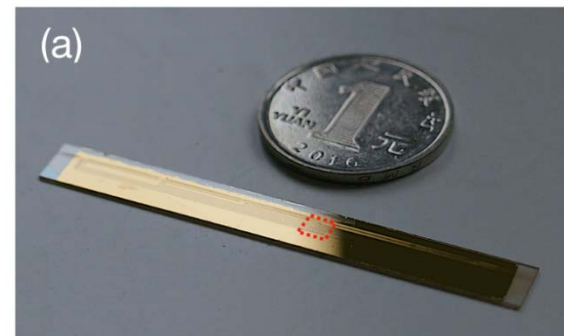
## I. 3D printing



## II. Microfluidics & chemistry chips



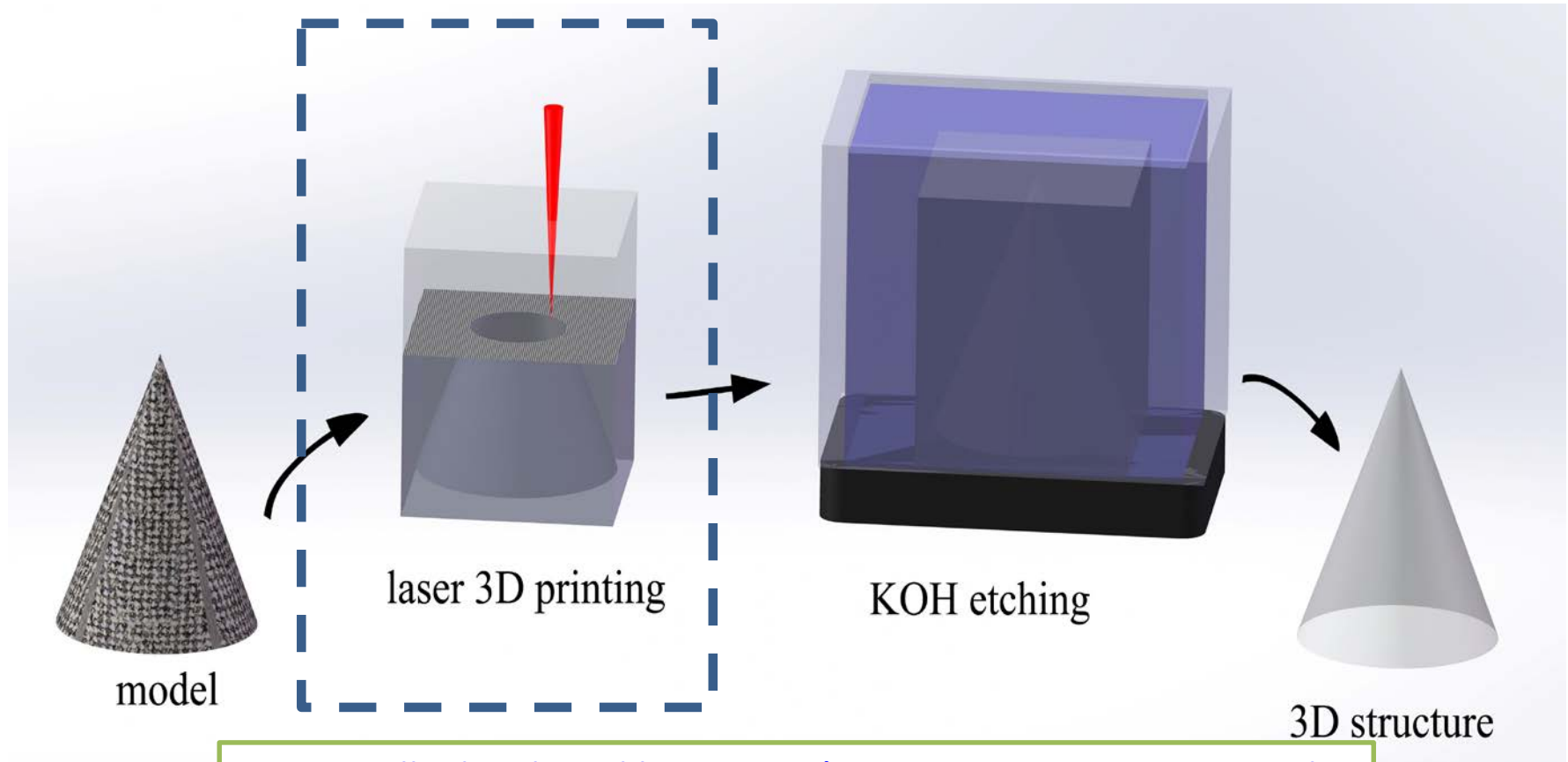
## III. Photonic chips



# I. 3D printing



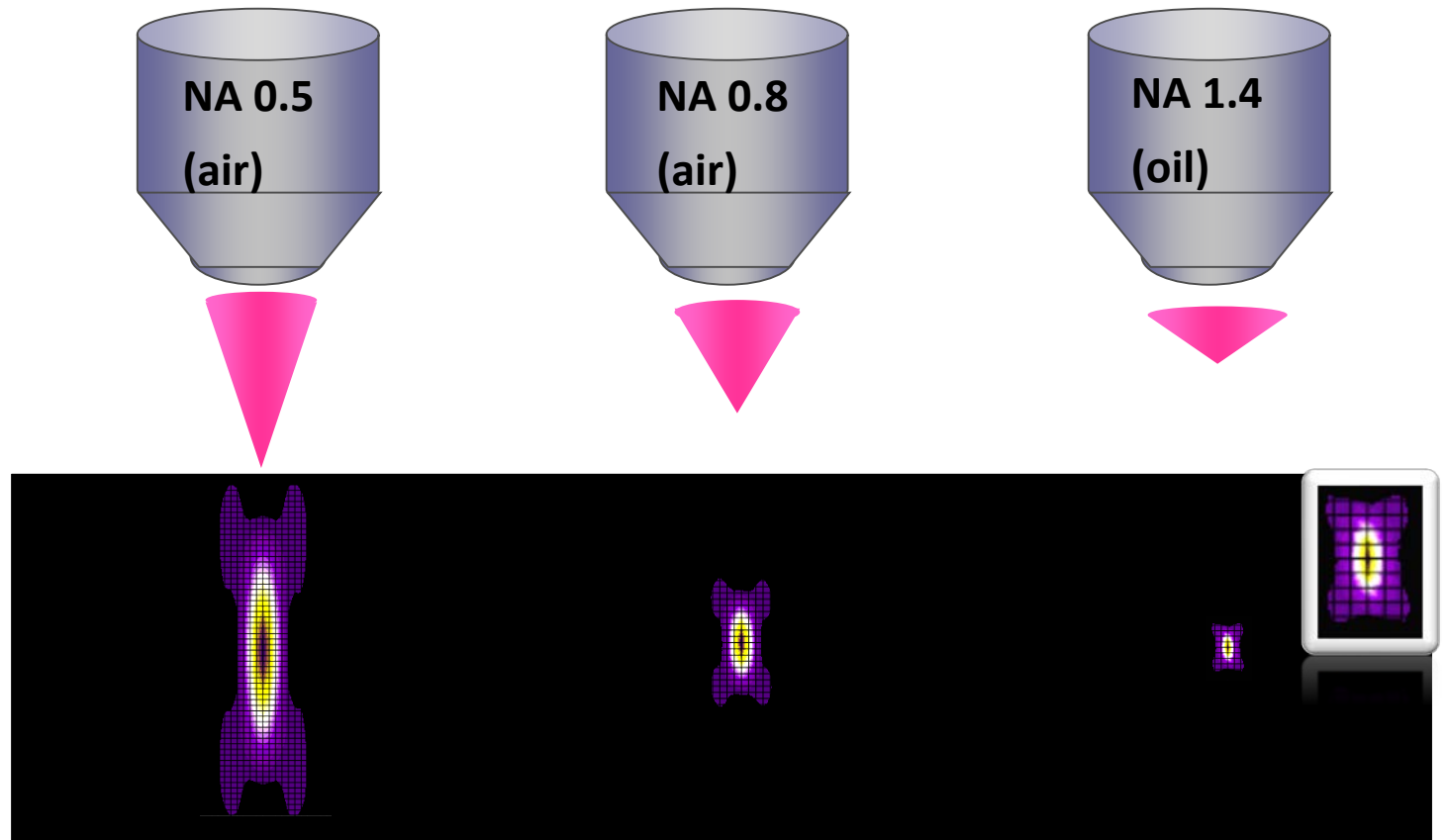
# Fabricate 3D glass structures: selective laser-induced etching



Originally developed by Misawa's group in Japan in 2001 and improved by many groups around the world later

A subtractive process that can produce structures with the original material properties.

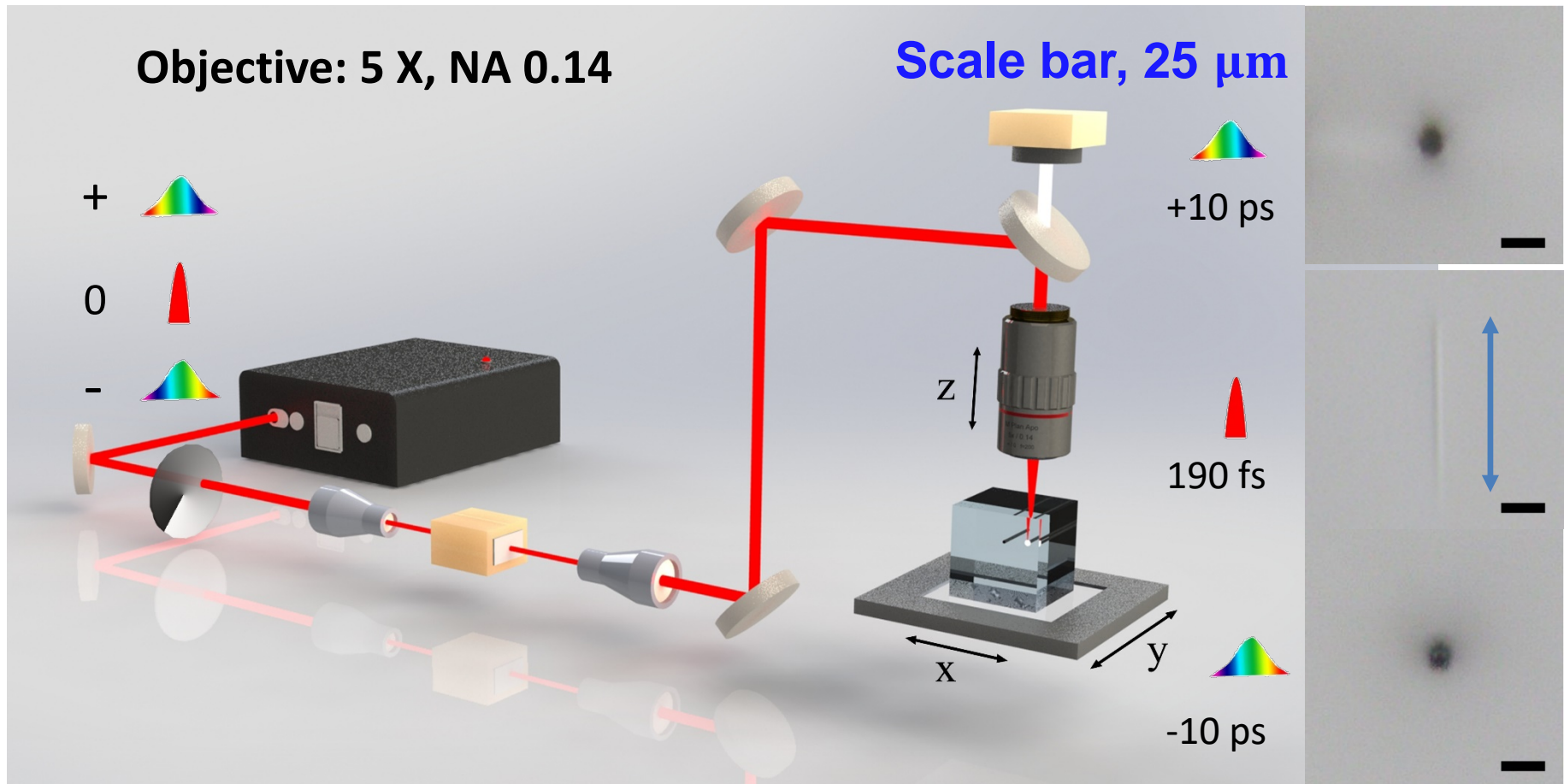
# Challenges: low axial resolutions with low NAs and aberration



**Large size**  
Low resolution

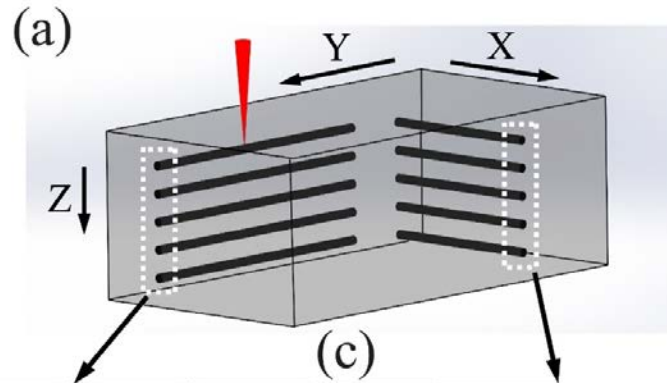
Small size  
**High resolution**

# Solution: picosecond laser modification

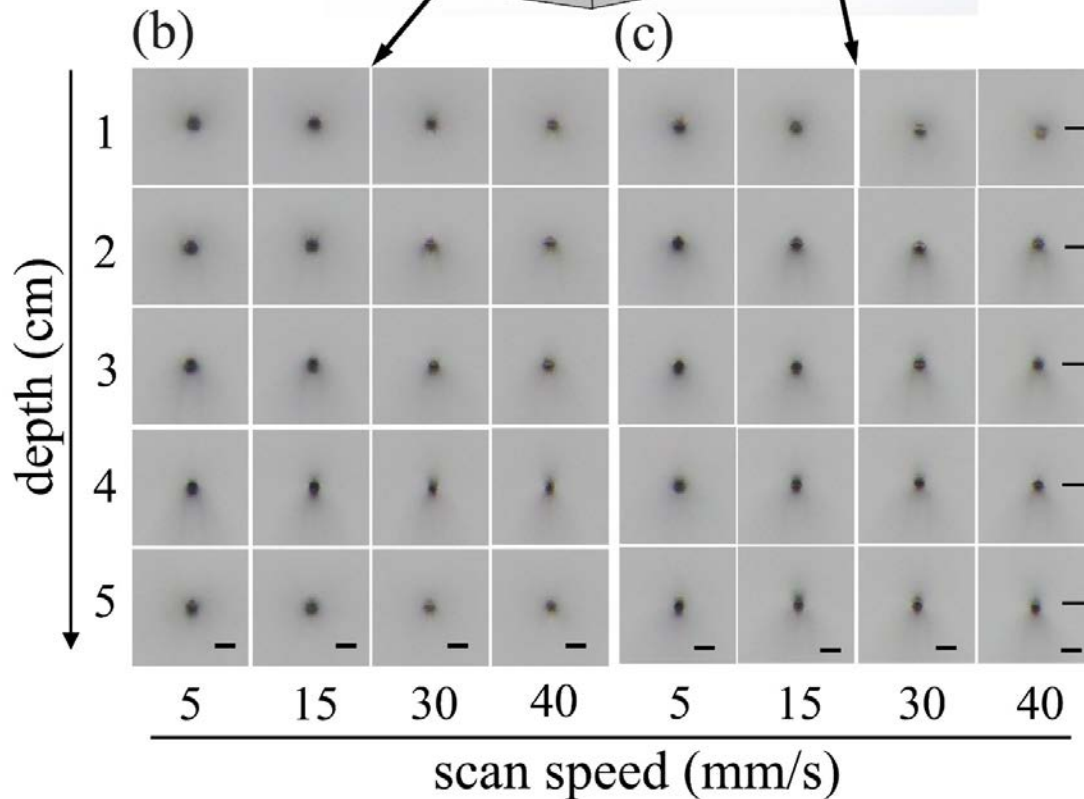


Y. Cheng, et al, Patent: 201910056960.2  
P. Wang et al, Micromachines 2019, 10, 565

# Uniform cross-section of lines at different depths



*Micromachines* **2019**, 10, 565

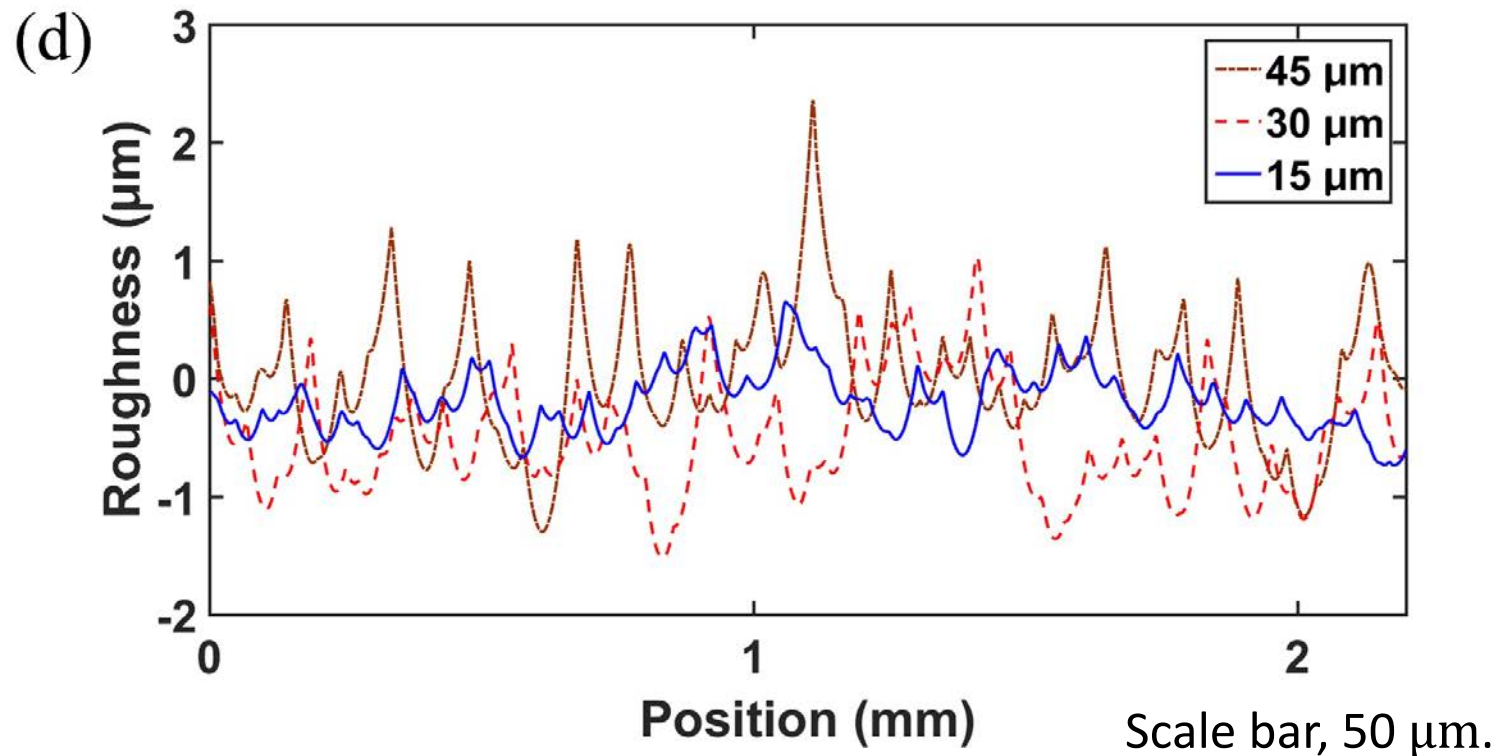
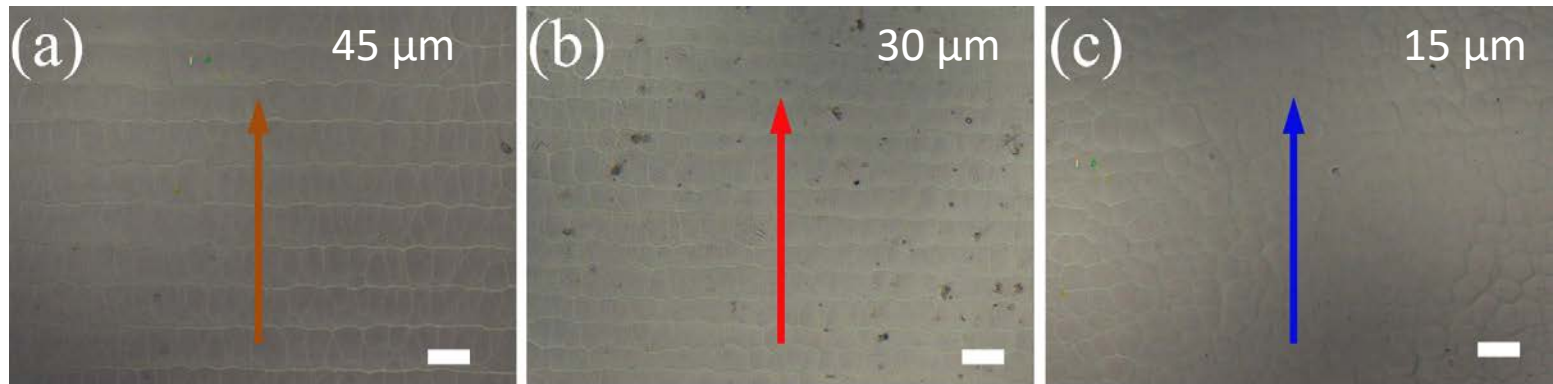


Spherical spot  
independent of

- depth
- direction
- speed

Scale bar, 25  $\mu\text{m}$ .

# Evidence showing a resolution of $\sim 15 \mu\text{m}$ in Z direction



# One more thing: chemical etching



We can produce isotropic, aberration-free modification in glass.

The chemical wet etching is dependent on the orientation of polarization of the writing beam. How can we remove such dependence to achieve homogeneous writing of complex 3D structures ?

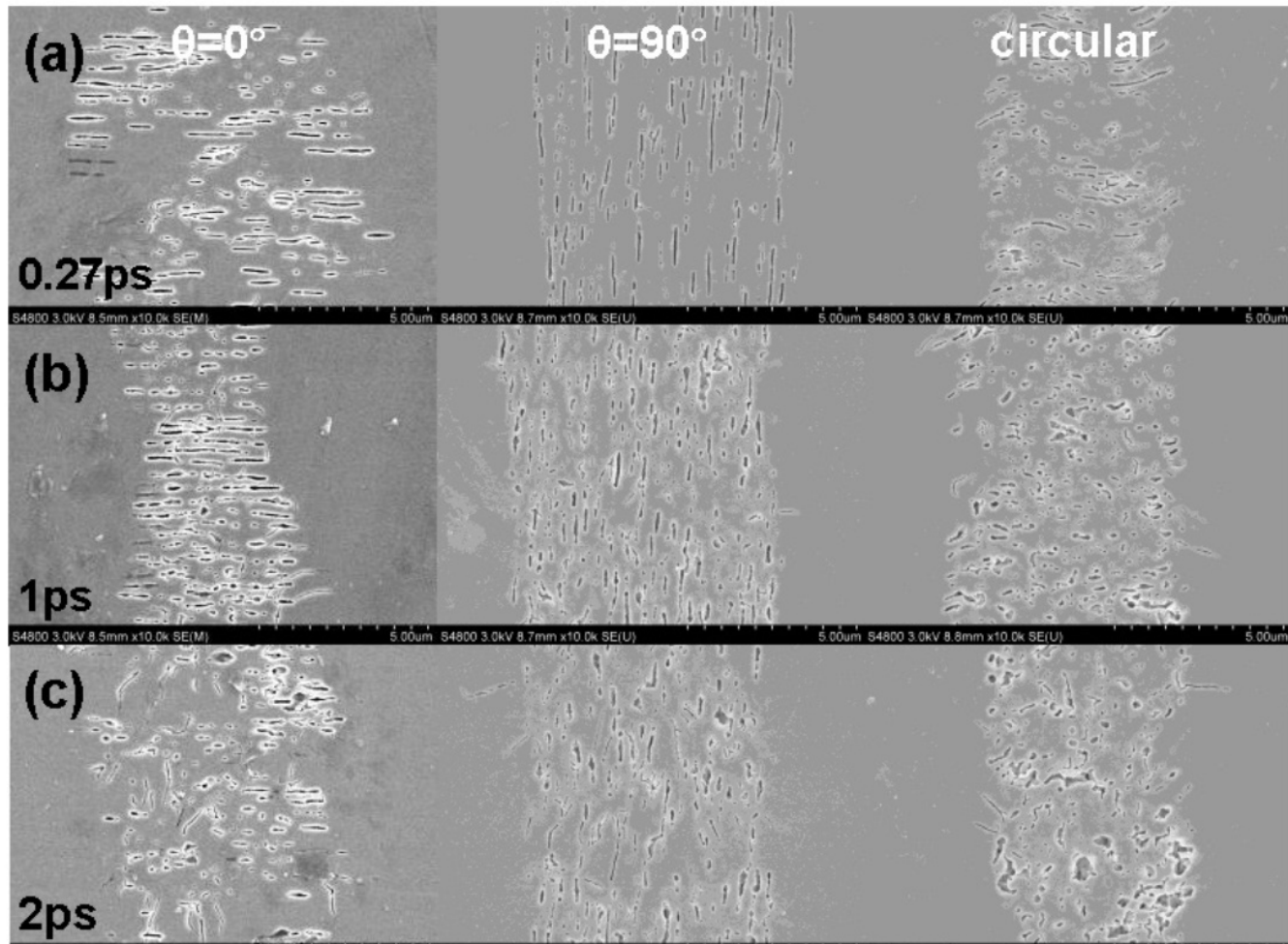
# Short pulses: nanogratings

Parallel

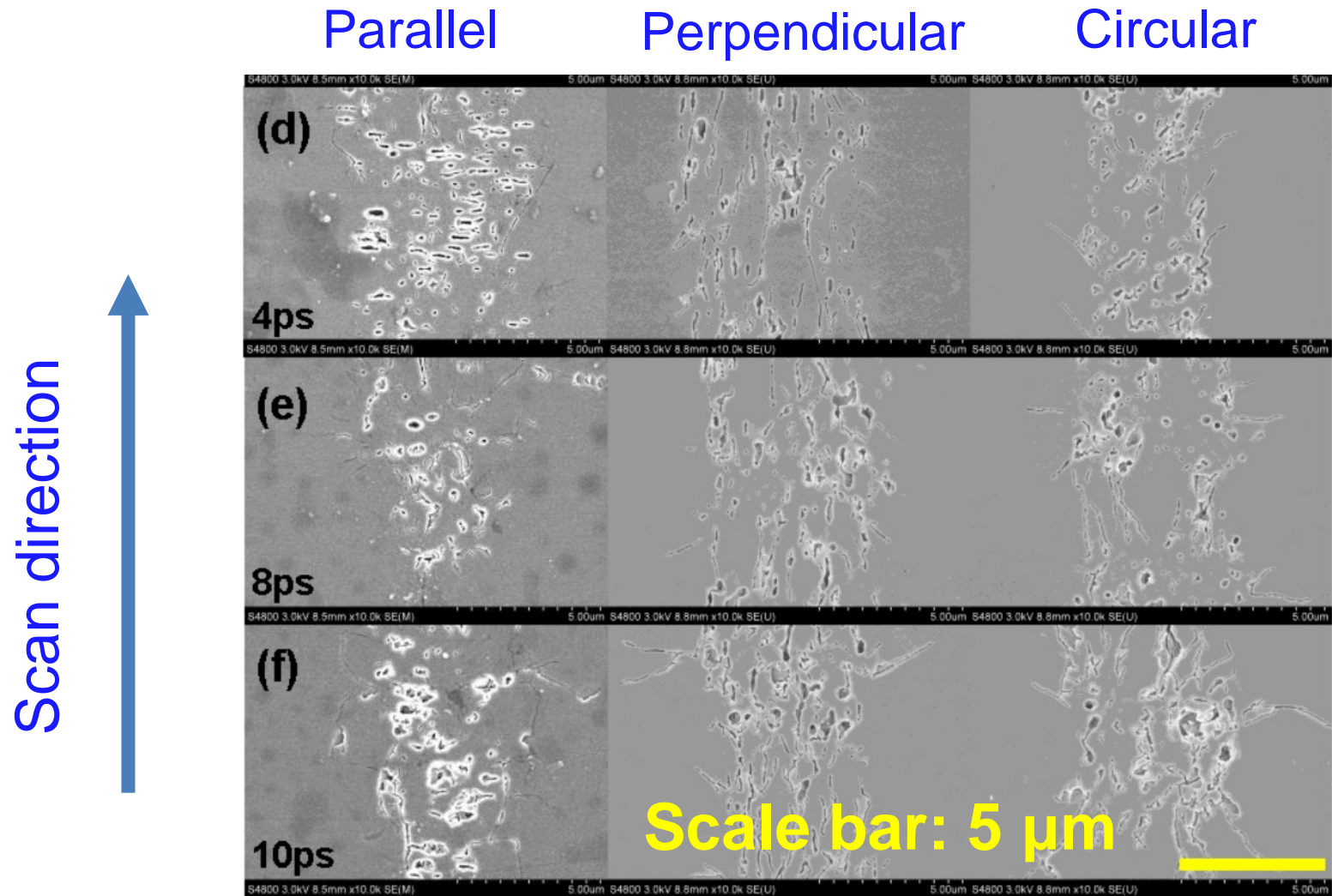
Perpendicular

Circular

Scan direction



# Longer pulses: stress induced cracks always along scan direction



Y. Cheng, et al, Patent: US16377138



# Polarization sensitivity vs pulse duration

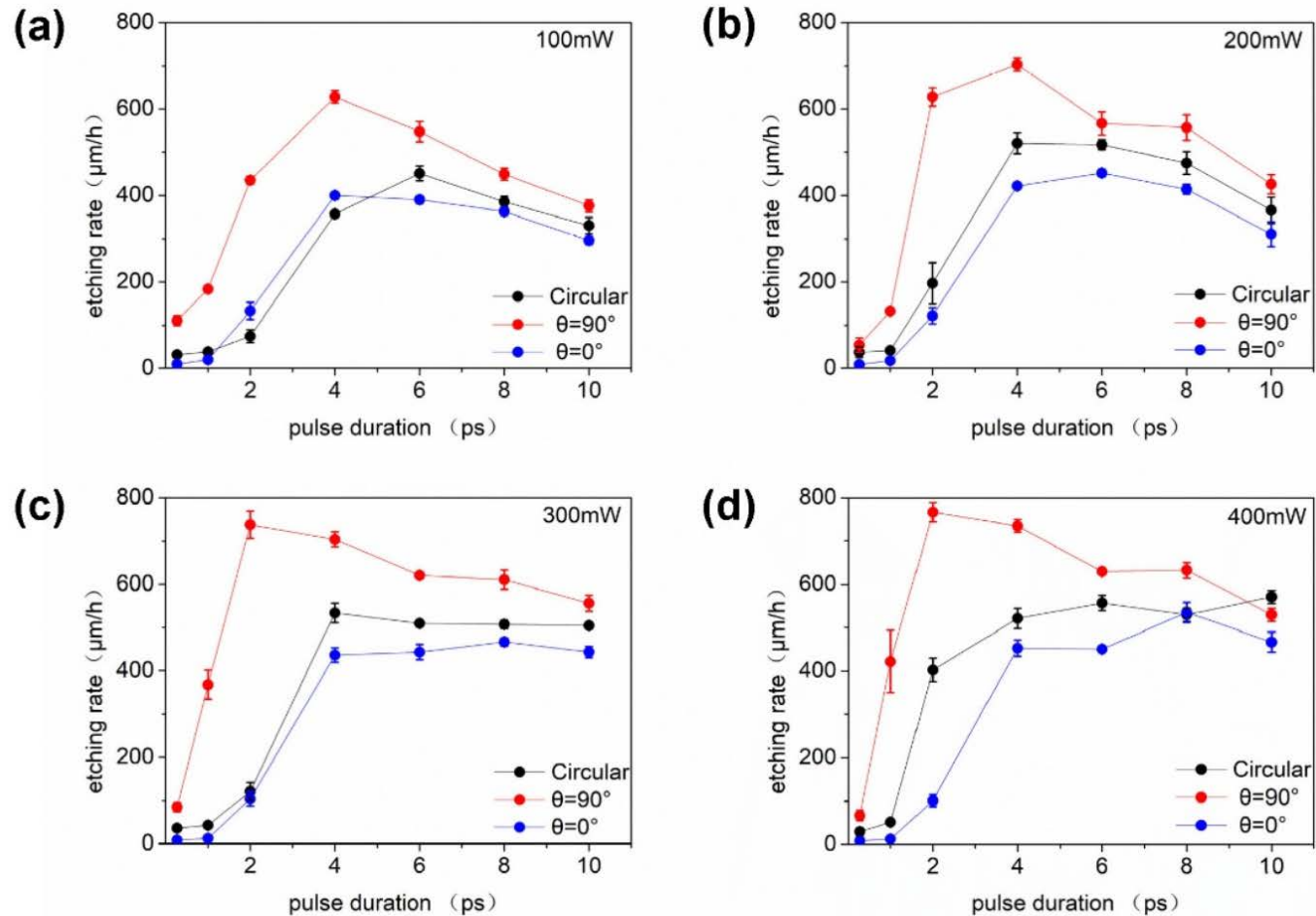
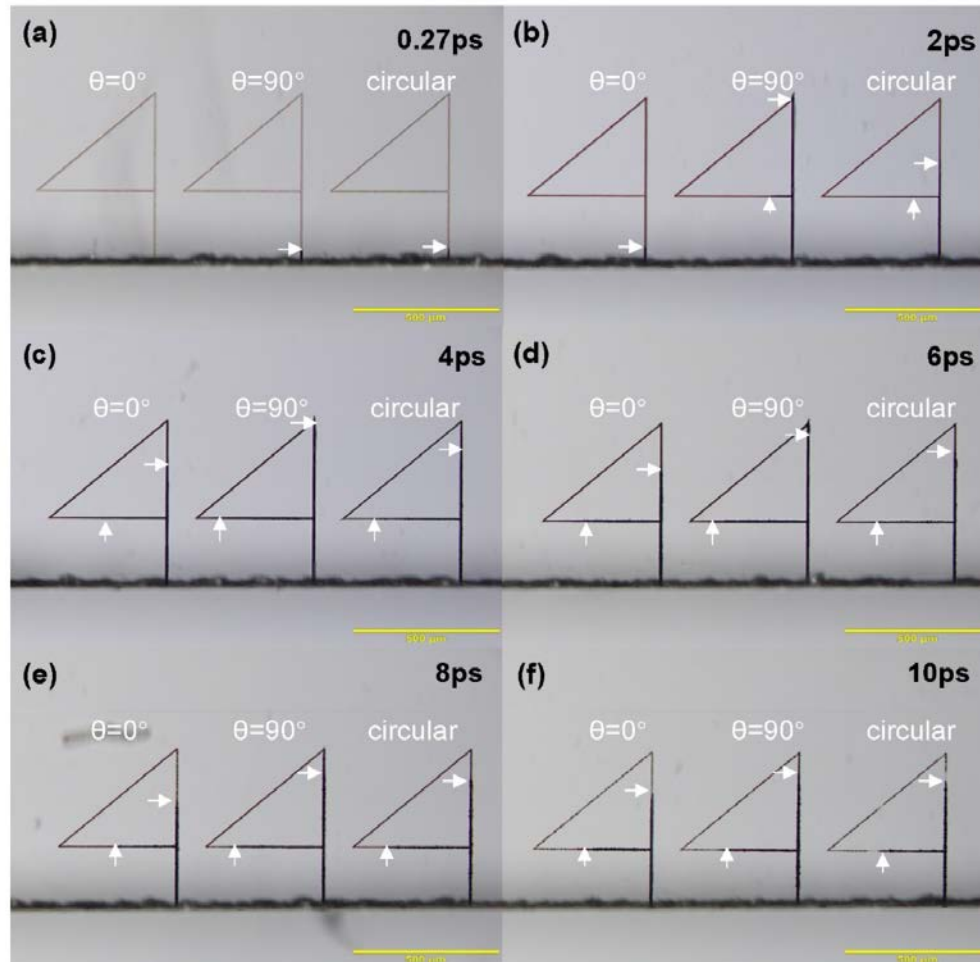


Fig. 2. Etching rates of laser modified lines in fused silica versus pulse durations at different polarization conditions and laser powers: (a) 100 mW; (b) 200 mW; (c) 300 mW; (d) 400 mW.

# Selective etching independent of polarization



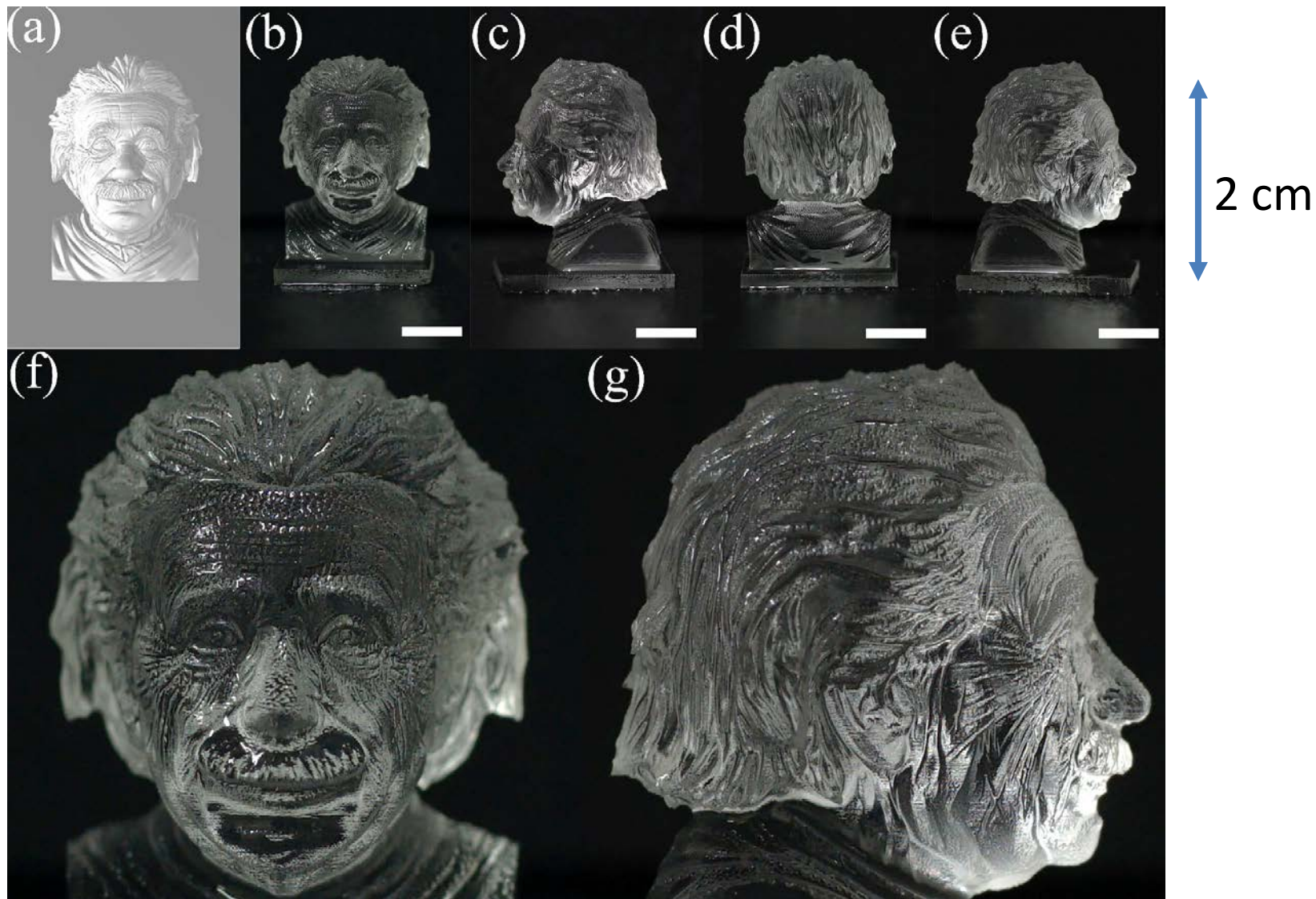
Applied Surface Science 485 (2019) 188–193



Maintain the high resolution at various depths.

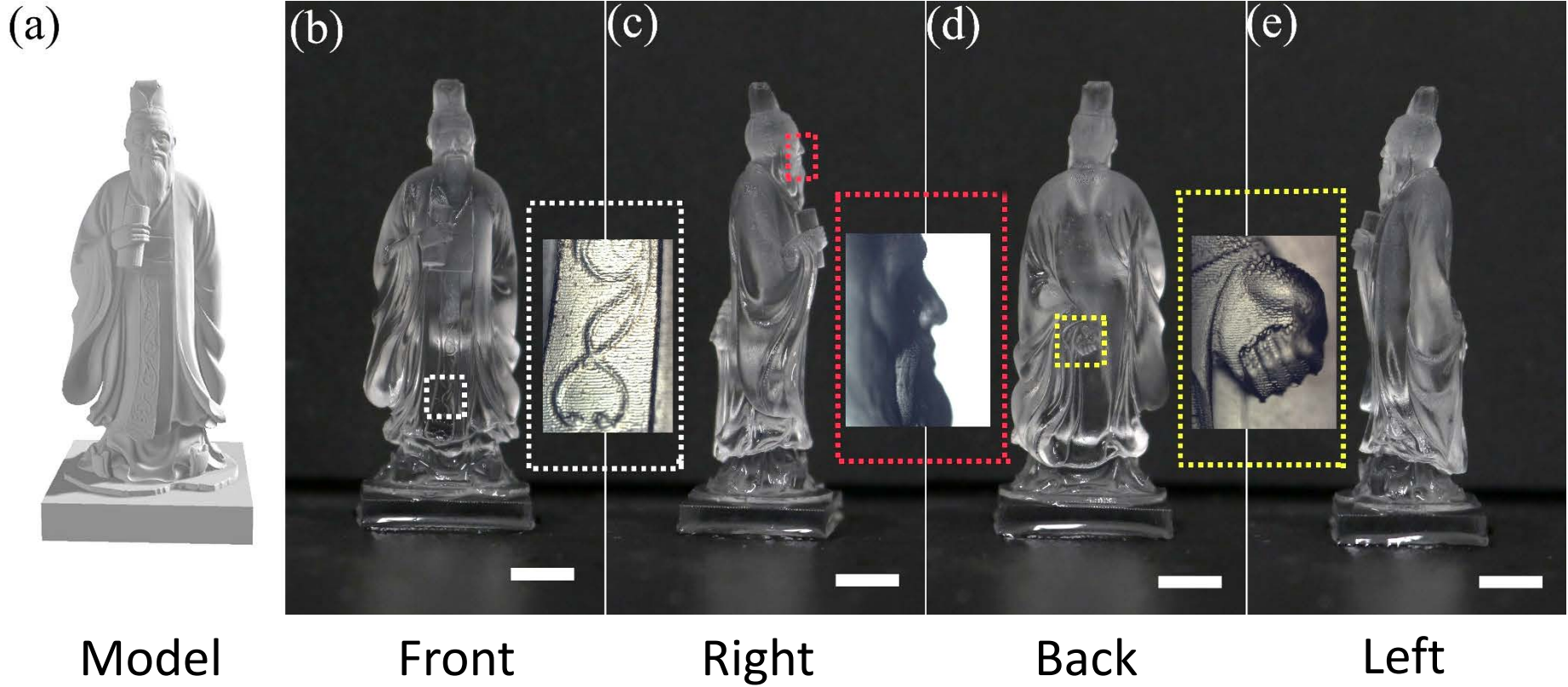
Achieve a polarization insensitive internal modification.

# Structures: Einstein of a height of 2 cm



Scale bar, 5 mm.

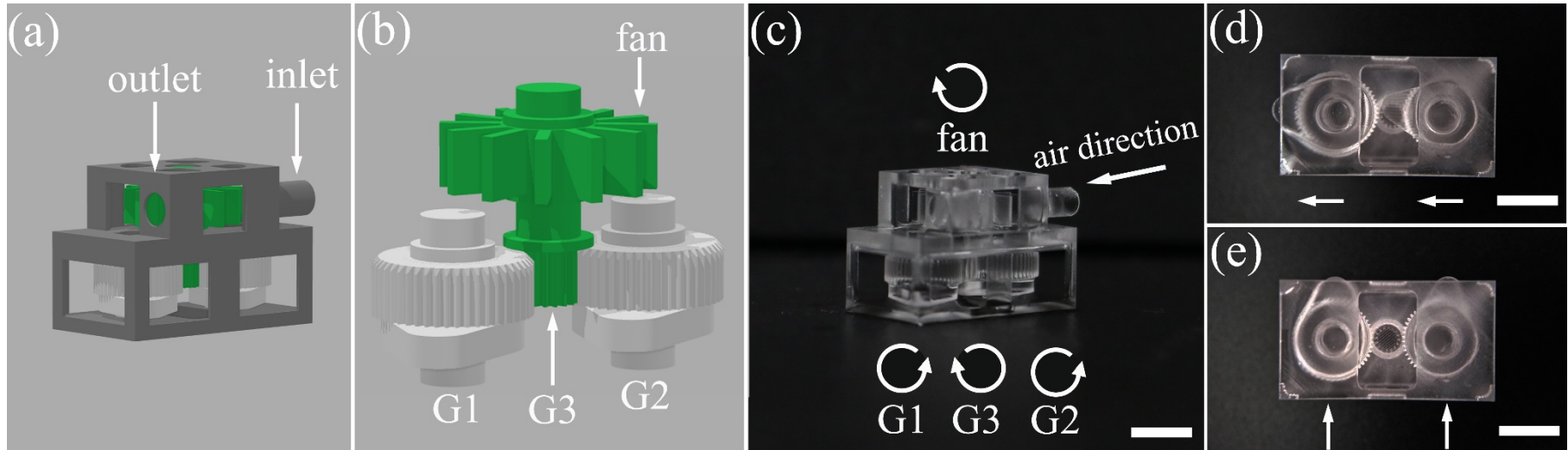
# Structures: Confucius of a height of 3.8 cm



*Micromachines* **2019**, *10*, 565

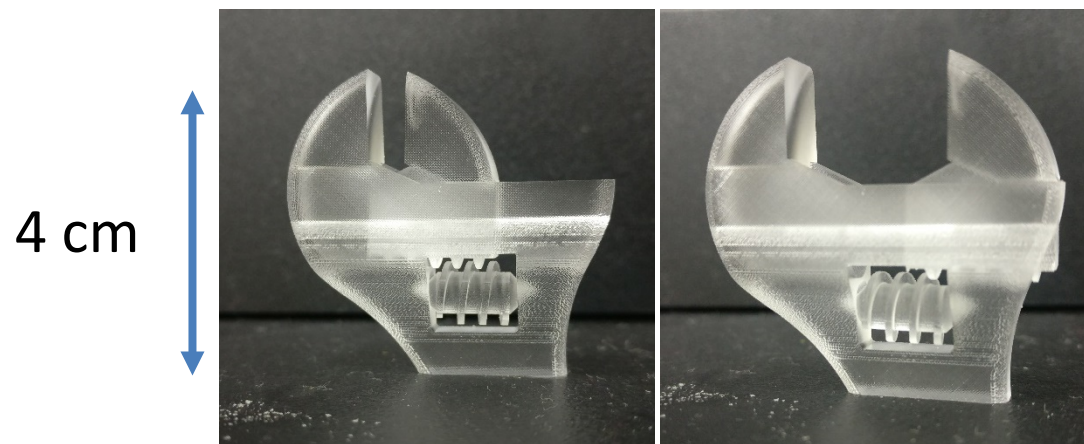
Scale bar, 5 mm.

# Structures: micromachines with movable parts



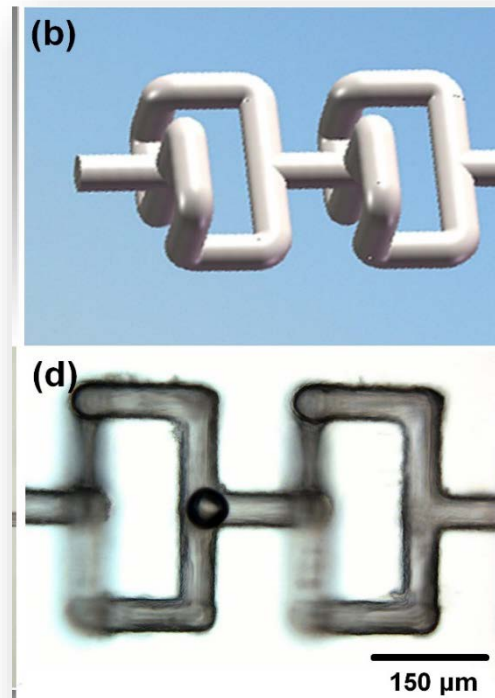
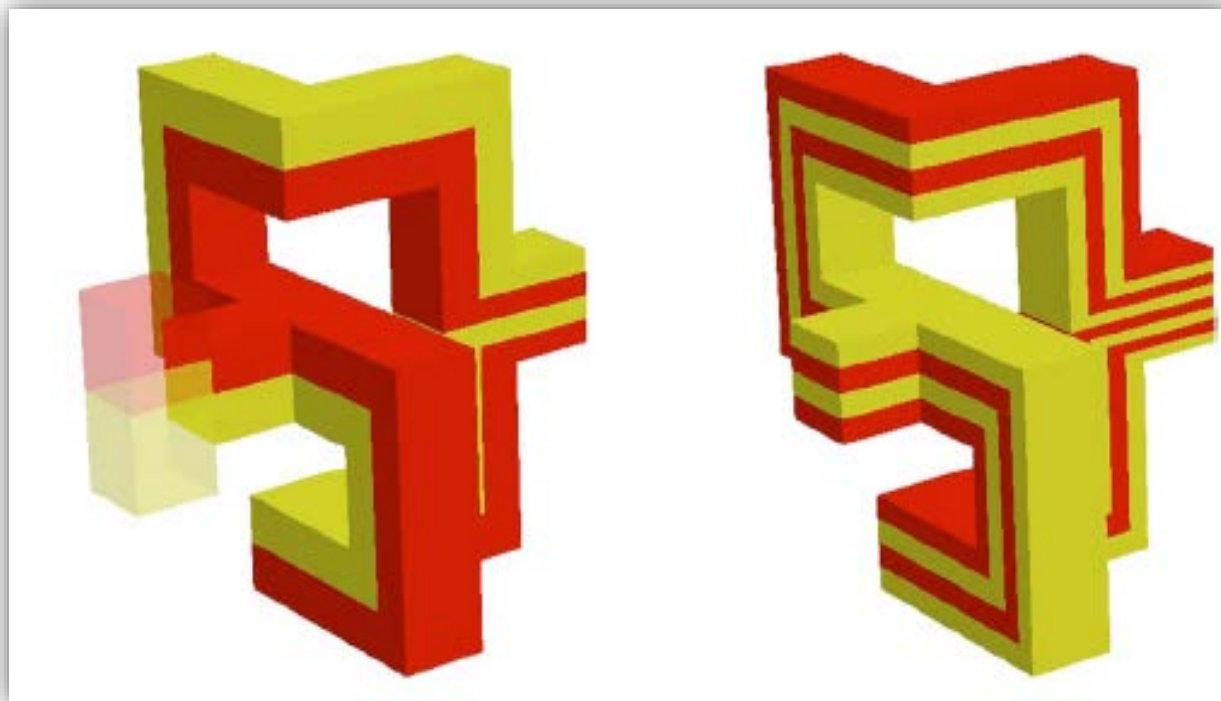
Air turbine

Scale bar, 5 mm.



## **II. Microfluidics & chemistry chips**

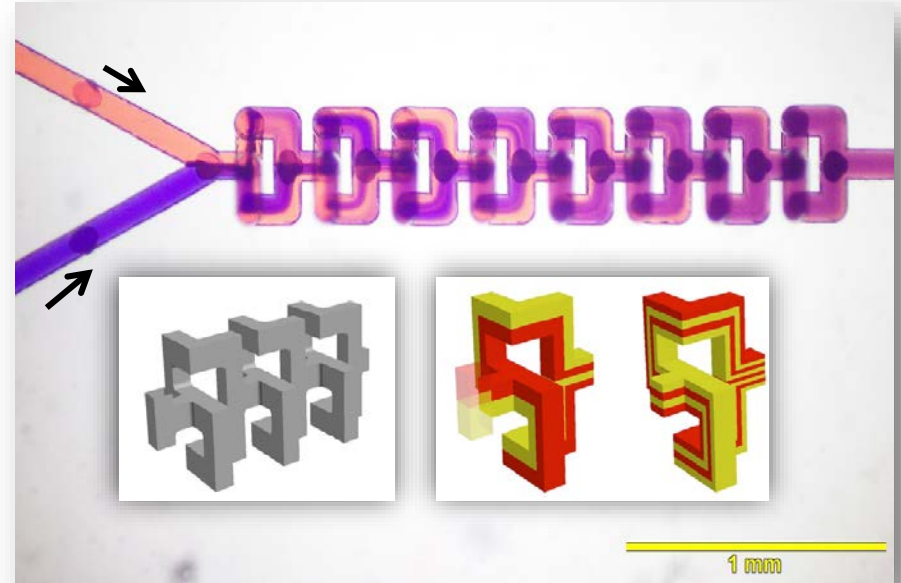
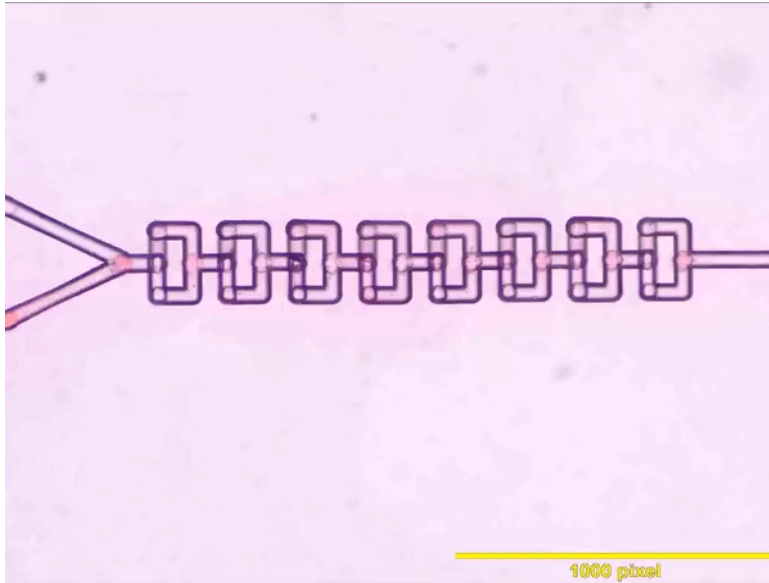
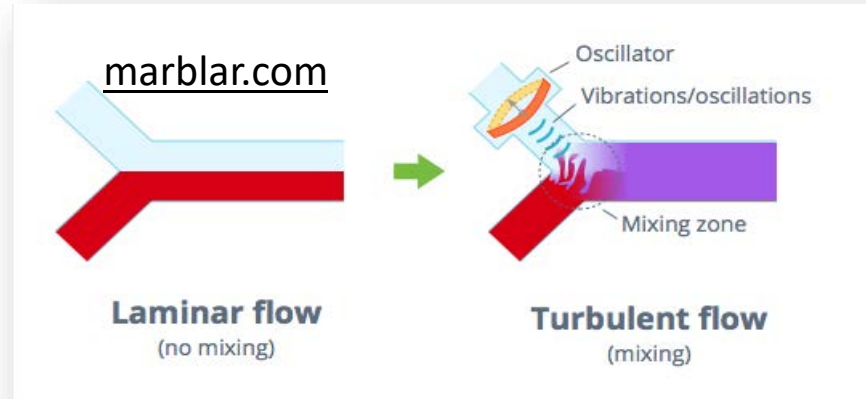
# 3D fluidic chip for higher mixing efficiency



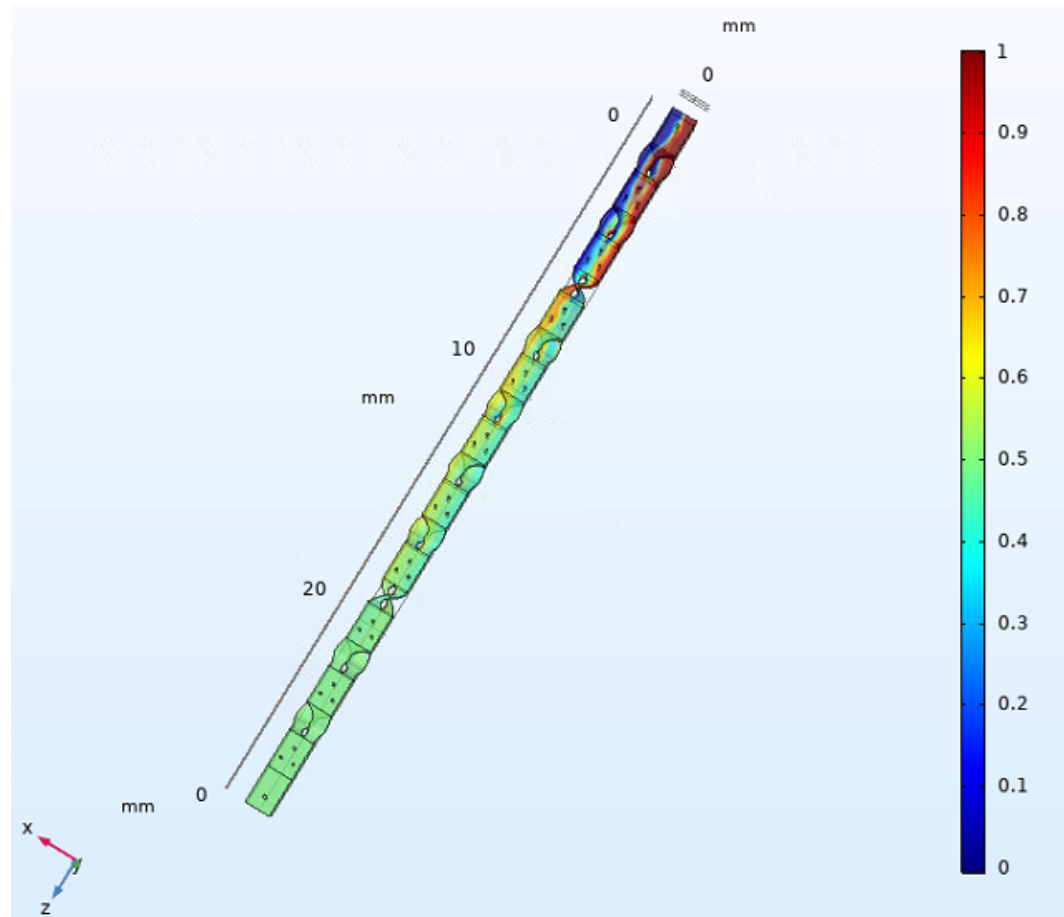
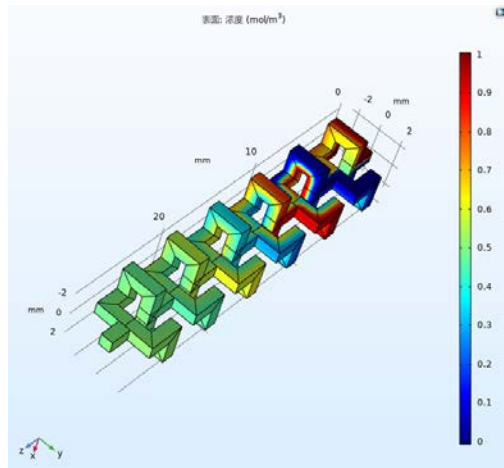
Y. Liao, et al., Lab. Chip 12, 746 (2012)



# Demonstration of high mixing efficiency



# Compact 3D mixer: smaller but more powerful

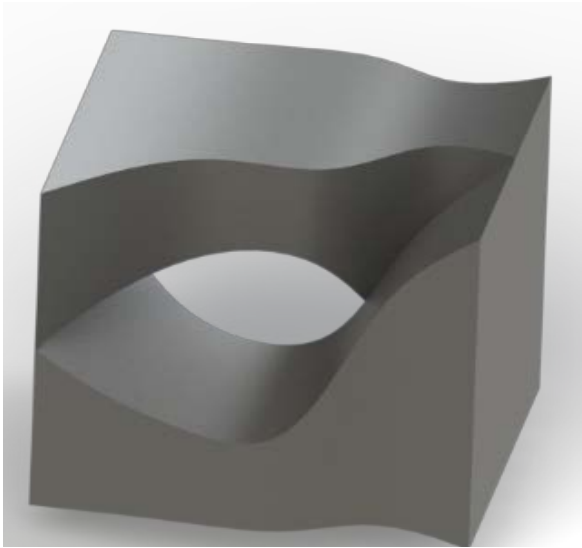


The 3D micro-mixer is efficient but it is also of a large footprint size for its "loose" 3D geometry.

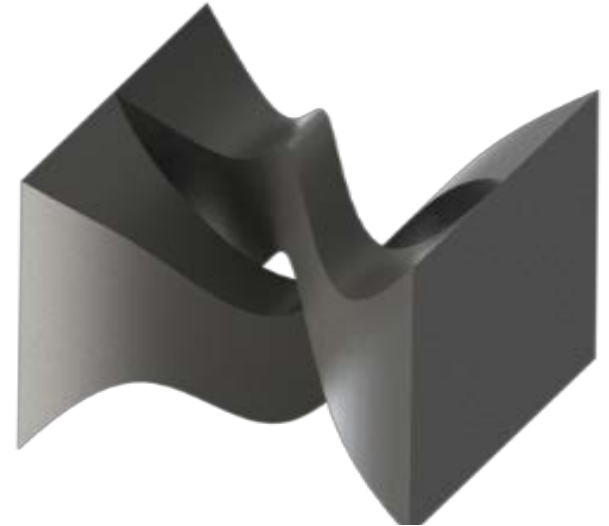
Accommodating a 3D micro-mixer in a planar channel to have a more compact geometry & higher mixing efficiency.

# Compact 3D mixer: the new design

Mixing unit 1

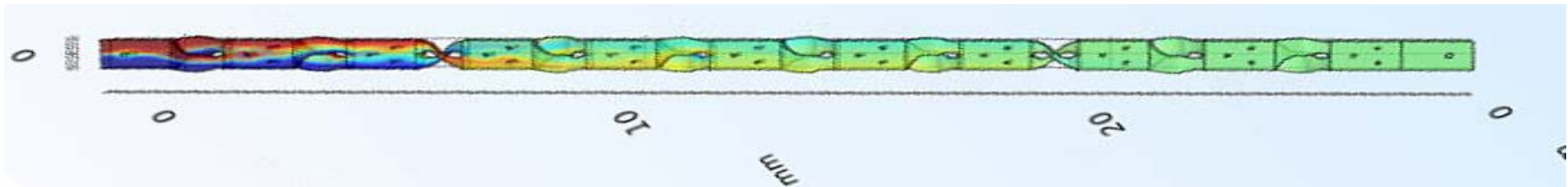


Mixing unit 2

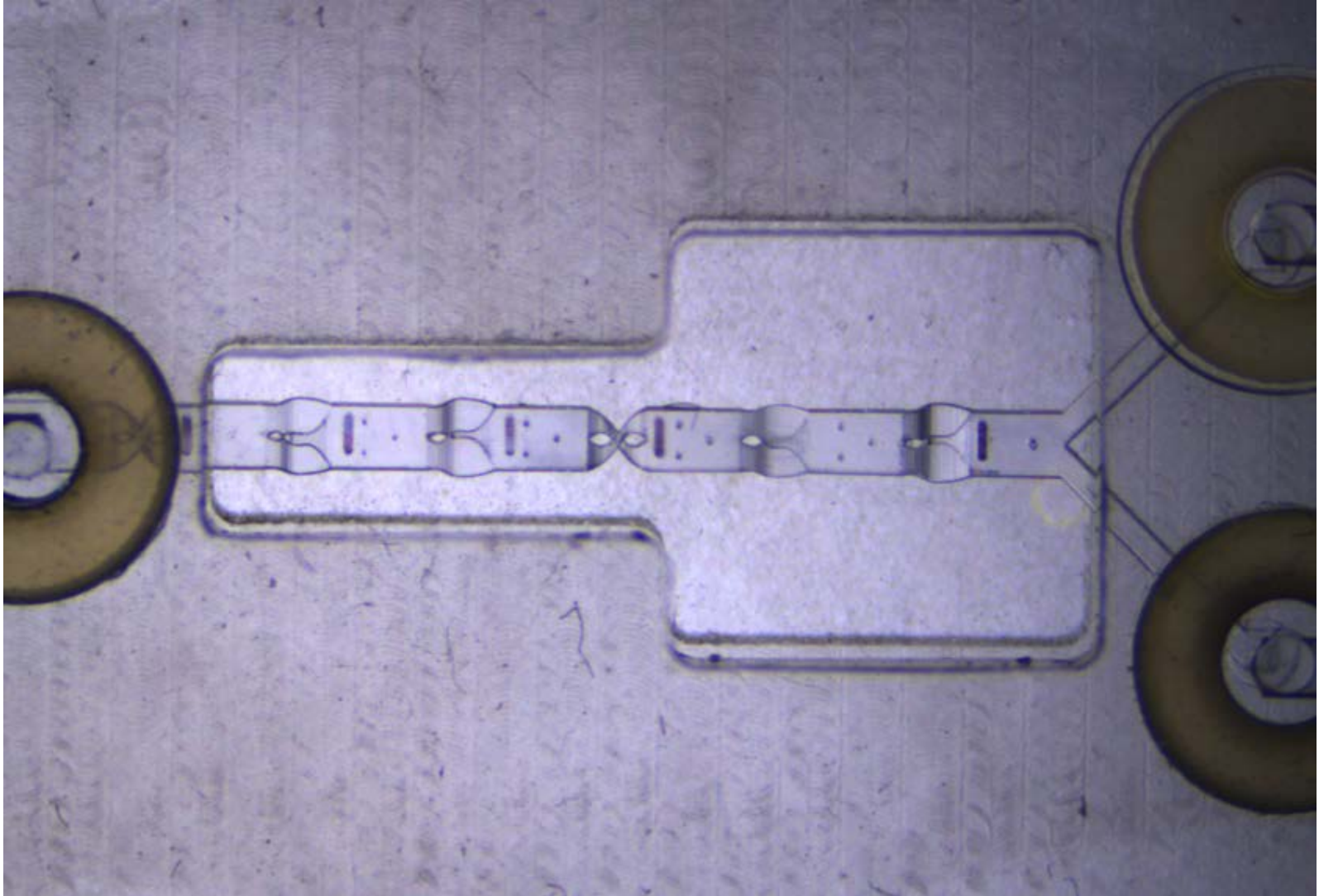


Mixing unit 1

Mixing unit 2

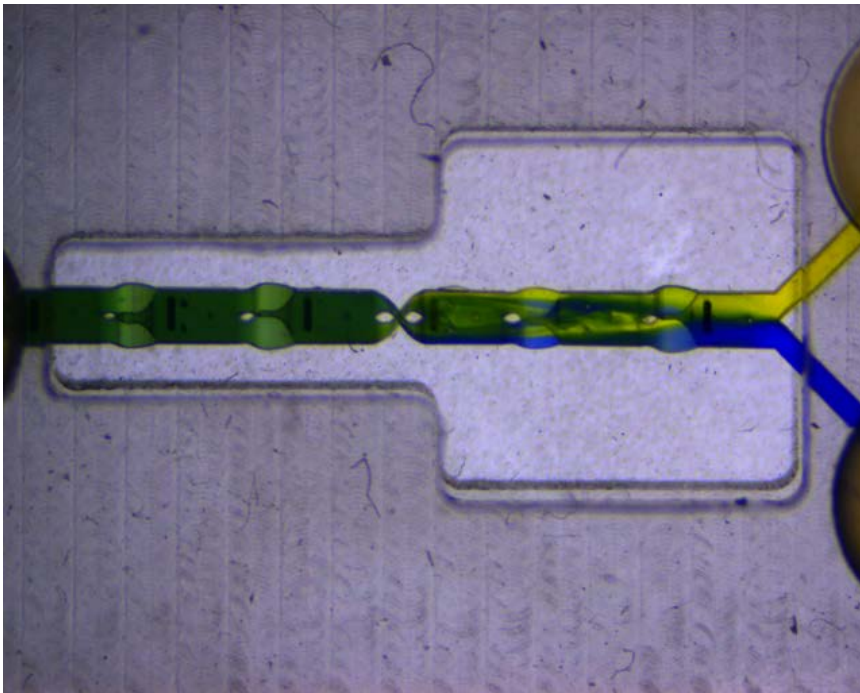


# Compact 3D mixer: fabricated device

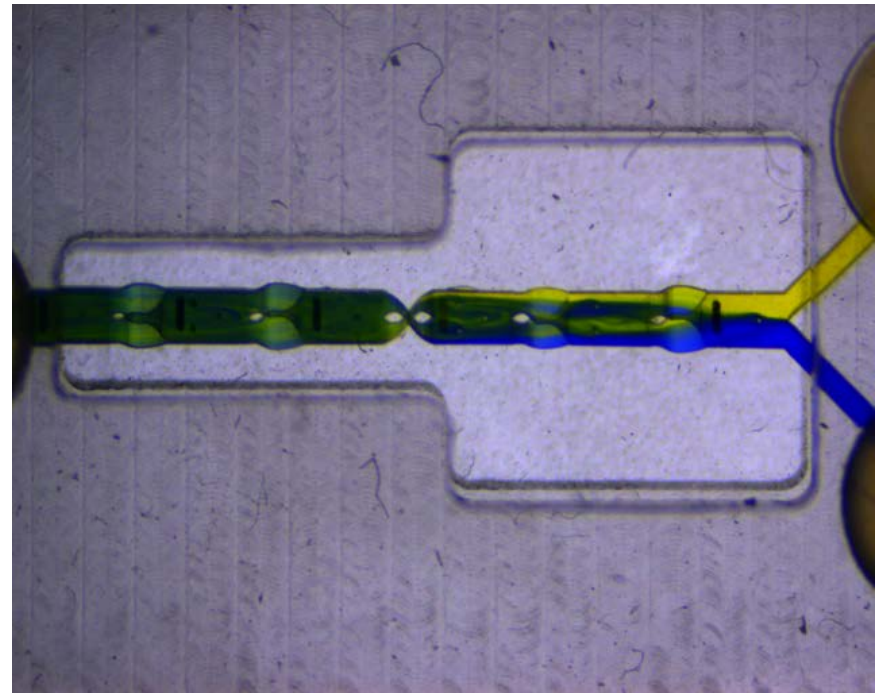


# Compact 3D mixer: the functionality

3ml/min

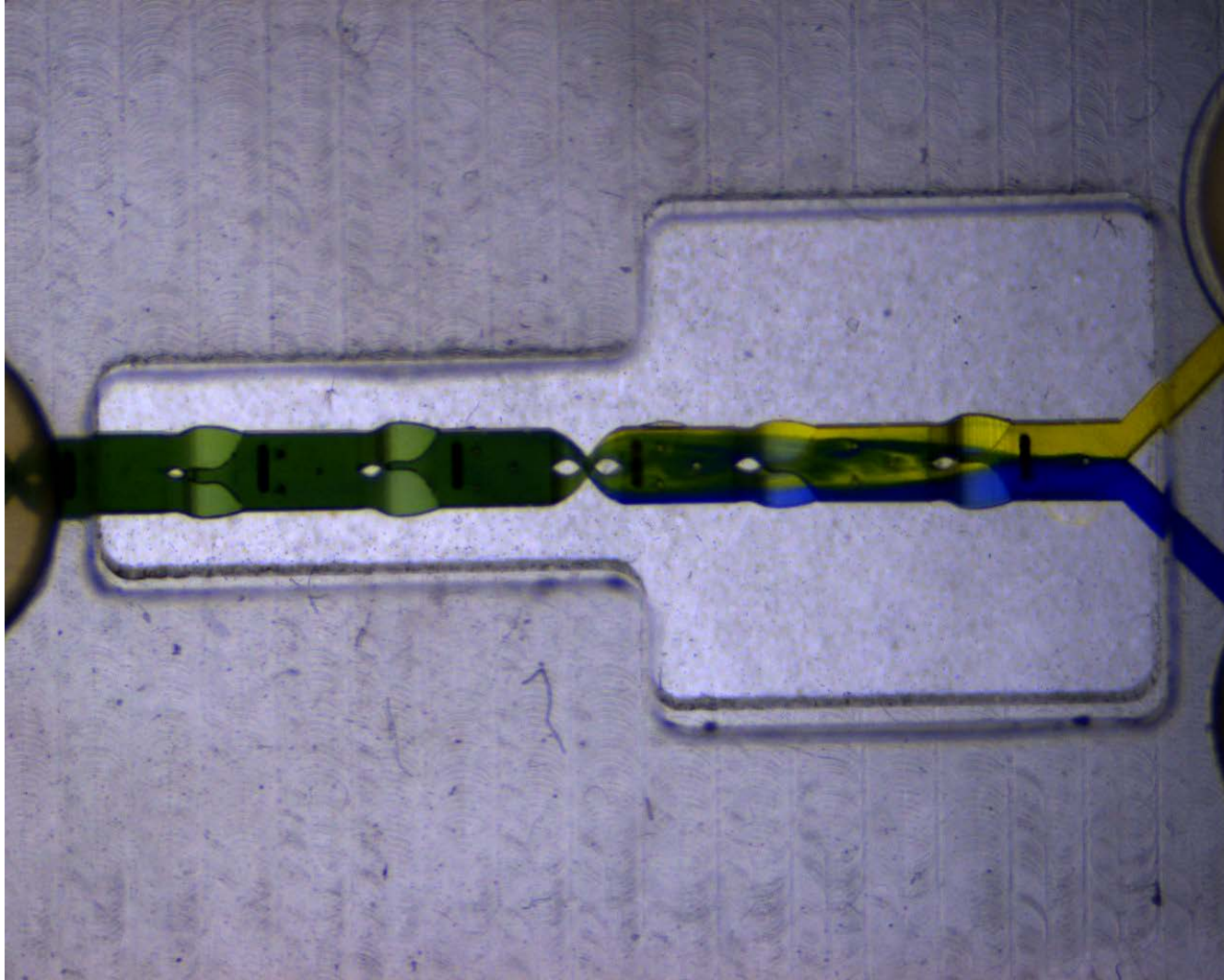


10ml/min



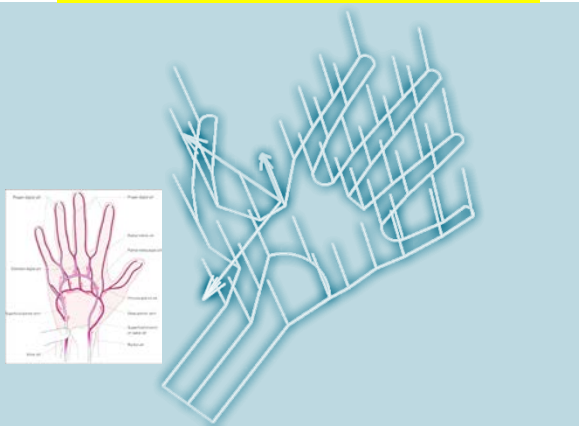
Total length: ~1 cm

# Mixing in the compact 3D micromixer



# Biological microfluidic circuits within human body

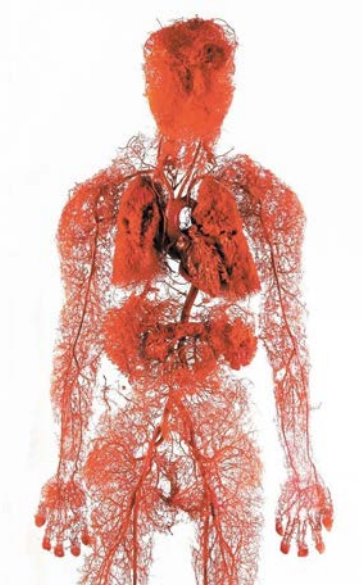
Microfluidic Circuit



Large-scale 3D printing

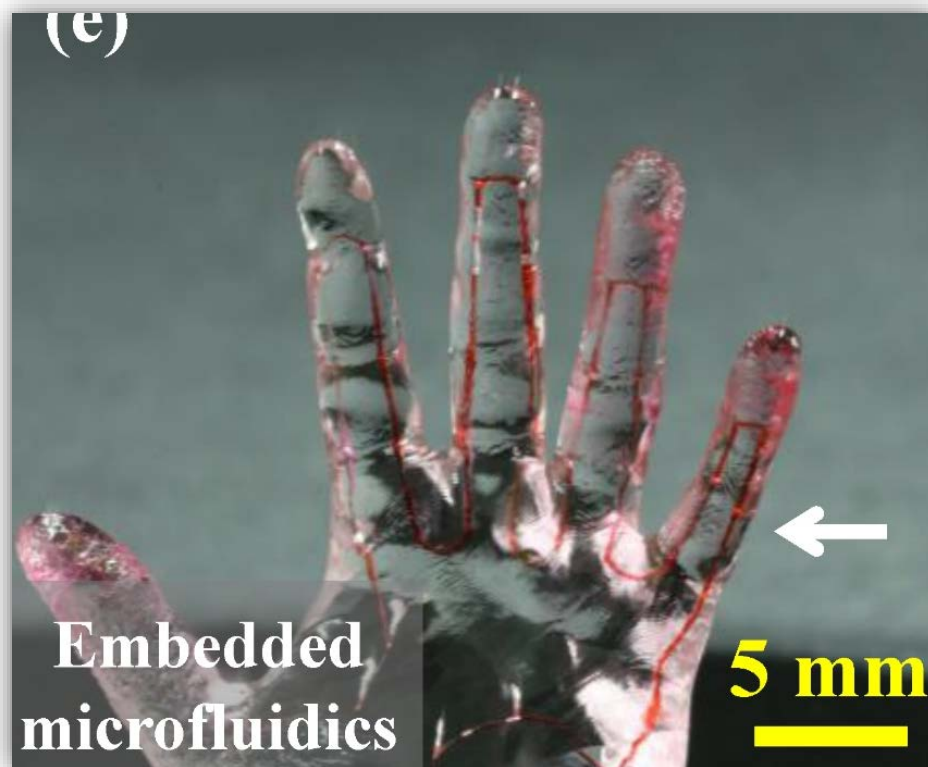
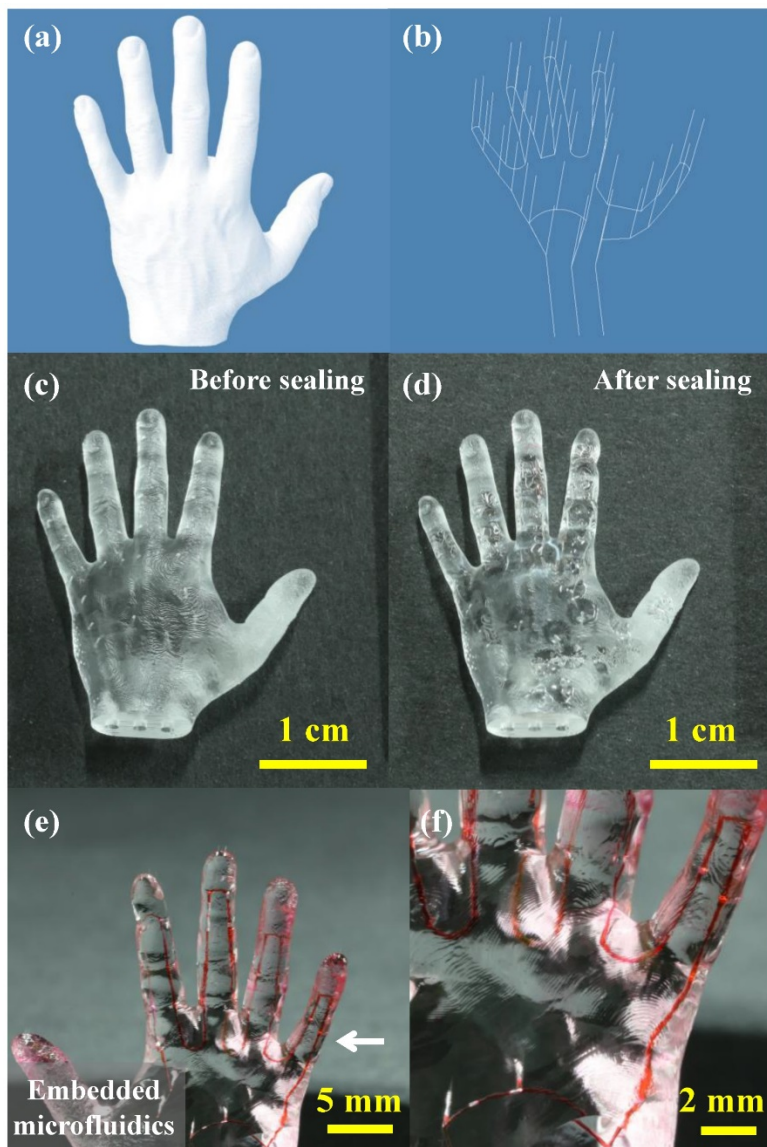


3D embedded blood vessels in glass



Promote understanding of the causes of human diseases such as cancers, cardiovascular diseases!

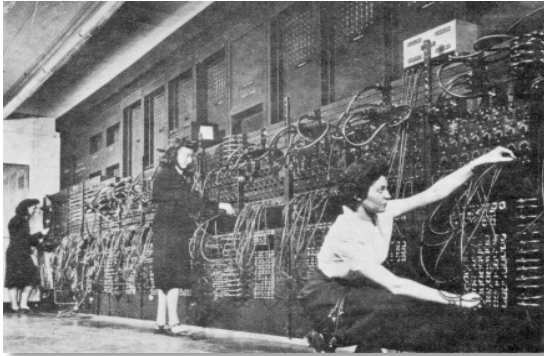
# A printed hand with embedded blood vessels



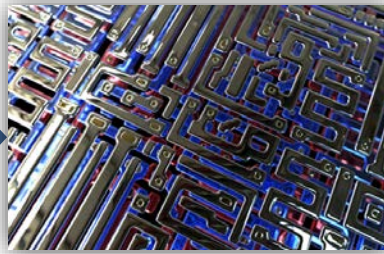


## **III. Photonic chips**

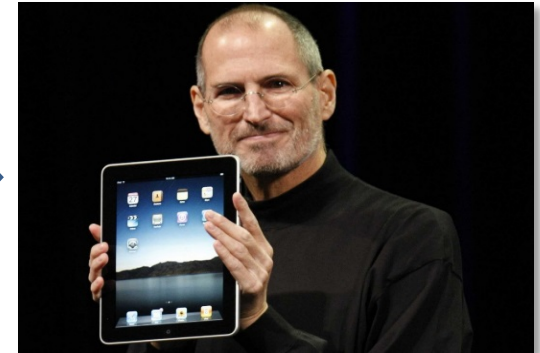
# From **Electronic ICs** to **Photonic ICs**



**First Generation  
Electronic Computer**



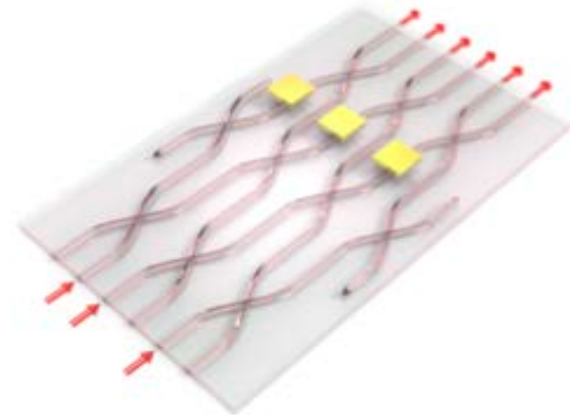
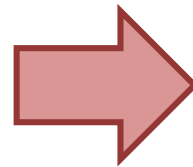
**Very-large scale  
integrated circuits**



**High-performance Electronic  
Information Products**



**Optical information  
processing platform**



**Photonic integrated  
circuits (PICs)**

# Crystalline PIC: Opportunities and Challenges

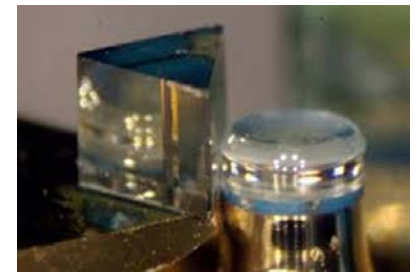
|                             | Nonlinear optical coefficients | Electro-optic coefficients |
|-----------------------------|--------------------------------|----------------------------|
| <b>Lithium niobite (LN)</b> | 41.7 pm/V                      | 30.9 pm/V                  |
| Quartz                      | 0.3 pm/V                       | 0.93 pm/V                  |

## Opportunities:

- Broad transmission window
- High nonlinear optical / electro-optic /thermal coefficients....

## Challenges:

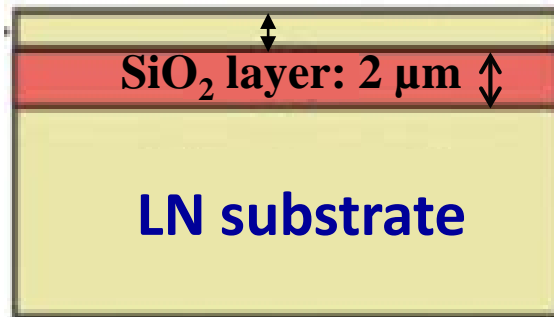
- **Hard to be patterned** by optical lithography
- High chemical stability



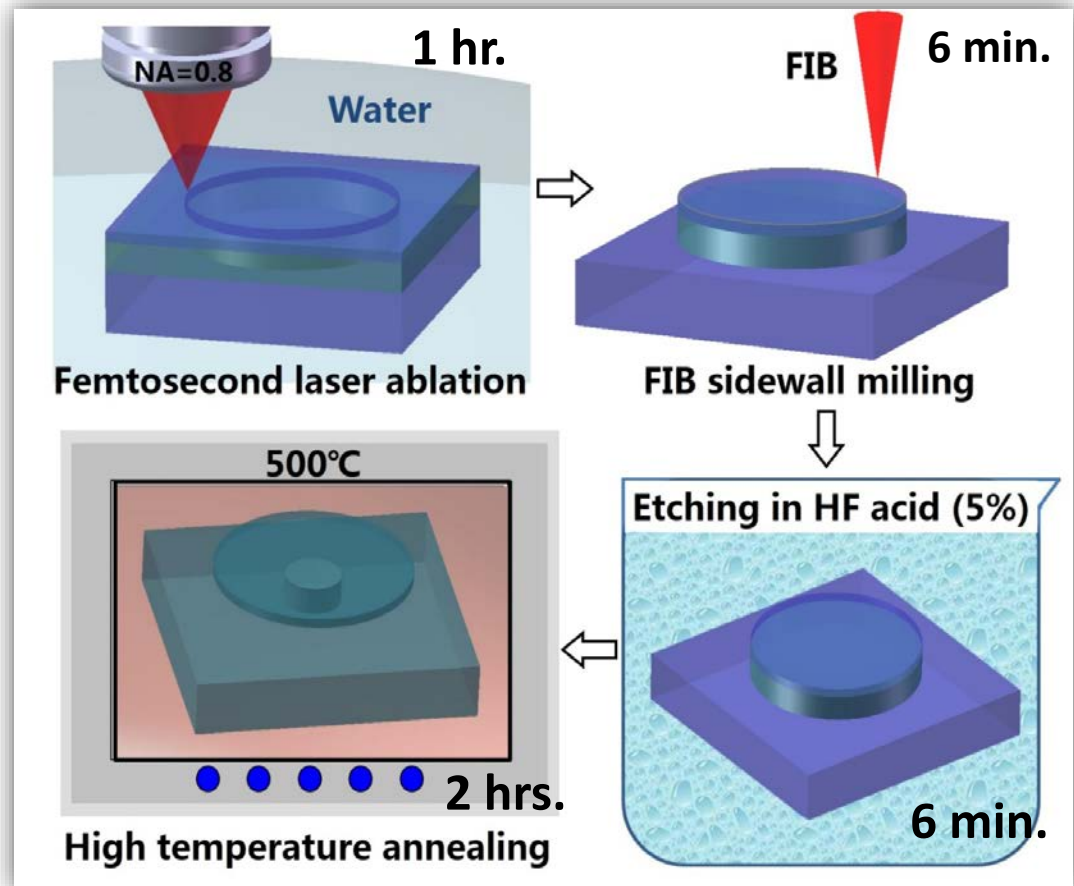
**First high-Q  
lithium niobate disk**

# High-Q microresonators on lithium niobate (LN)

LN thin film: 700 nm, Z-cut



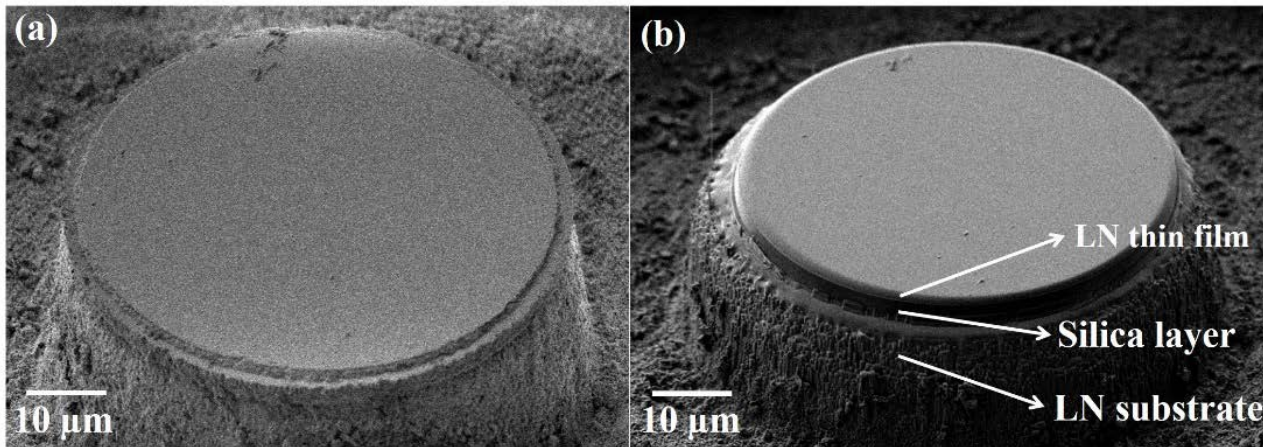
Laser Photon Rev.  
6, 488 (2012)



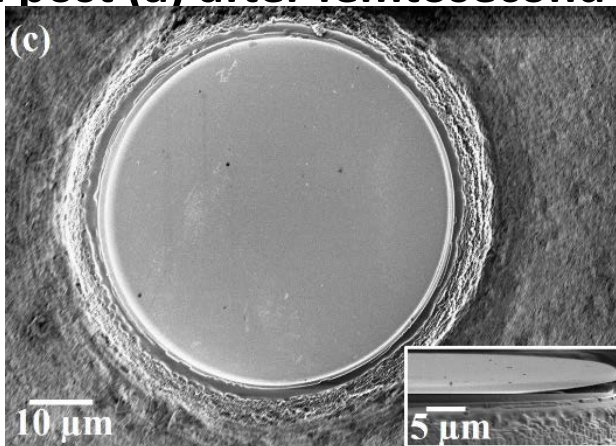
Fabrication procedure

J. Lin, et al, arXiv: 1405.6473 (Mar. 2014, beginning of on-chip high Q LN microresonators)

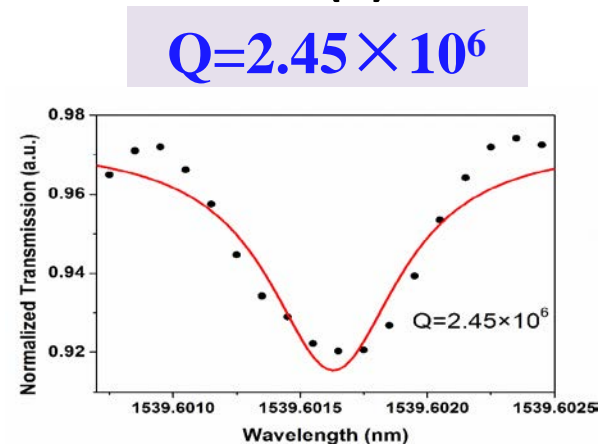
# High-Q microresonators on lithium niobate (LN)



Cylindrical post (a) after femtosecond laser ablation and (b) after the FIB milling

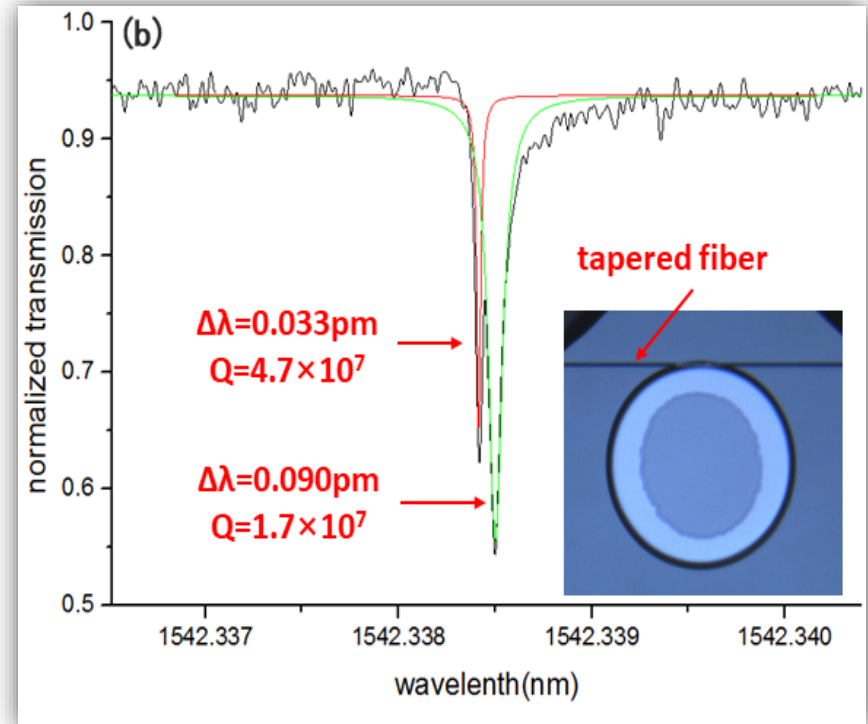
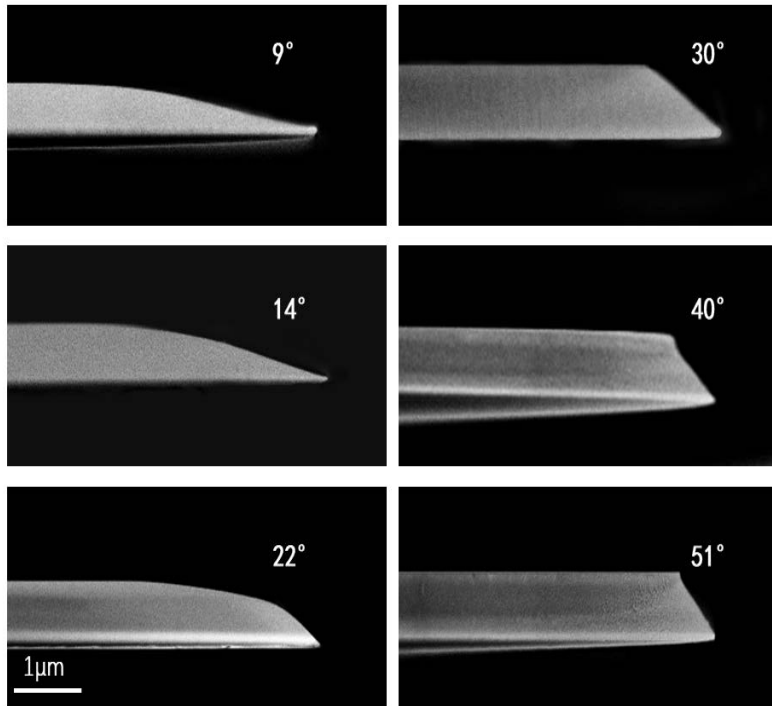


(c) SEM image (top view) of the microresonator, inset: side view.



J. Lin, et al, arXiv:1405.6473 (2014); Sci. Rep. 5, 8072 (2015)

# High Q microdisks with tunable wedge angle



J. Zhang, et al, Nanomaterials 2019, 9, 1218;  
doi:10.3390/nano9091218

$$Q \sim 4.7 \times 10^7$$

# Nonlinear optics with the high-Q microdisks

PHYSICAL REVIEW LETTERS 122, 173903 (2019)

## Broadband Quasi-Phase-Matched Harmonic Generation in an On-Chip Monocrystalline Lithium Niobate Microdisk Resonator

Jintian Lin,<sup>1,\*</sup> Ni Yao,<sup>2,†</sup> Zhenzhong Hao,<sup>3</sup> Jianhao Zhang,<sup>1,5</sup> Wenbo Mao,<sup>3</sup> Min Wang,<sup>4</sup> Wei Chu,<sup>1</sup> Rongbo Wu,<sup>1,5</sup> Zhiwei Fang,<sup>4</sup> Lingling Qiao,<sup>1</sup> Wei Fang,<sup>2,†</sup> Fang Bo,<sup>3,4</sup> and Ya Cheng<sup>1,4,5,6,8</sup>

<sup>1</sup>State Key Laboratory of High Field Laser Physics, Shanghai Institute of Optics and Fine Mechanics, Chinese Academy of Sciences, Shanghai 201800, China

<sup>2</sup>State Key Laboratory of Modern Optical Instrumentation, College of Optical Science and Engineering, Zhejiang University, Hangzhou 310027, China

<sup>3</sup>The MOE Key Laboratory of Weak Light Nonlinear Photonics, TEDA Applied Physics Institute and School of Physics, Nankai University, Tianjin 300457, China

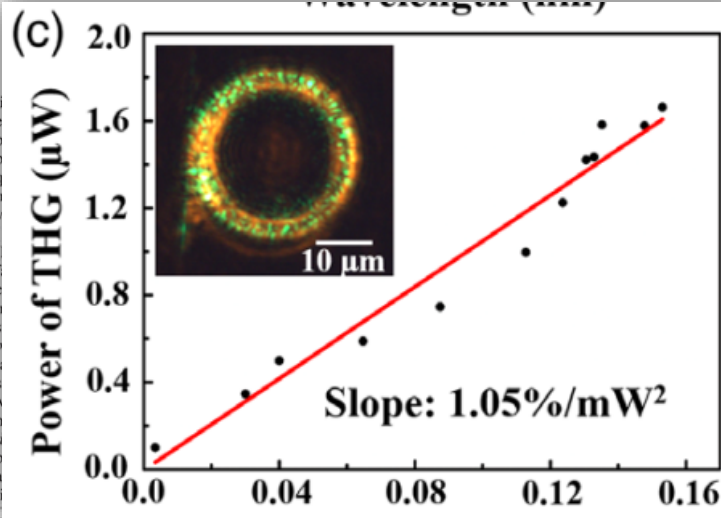
<sup>4</sup>State Key Laboratory of Precision Spectroscopy, East China Normal University, Shanghai 200062, China

<sup>5</sup>University of Chinese Academy of Sciences, Beijing 100049, China

<sup>6</sup>Collaborative Innovation Center of Extreme Optics, Shanxi University, Taiyuan, Shanxi 030006, China

(Received 16 October 2018; published 3 May 2019)

We reveal a unique broadband natural quasi-phase-matching (QPM) mechanism underlying an observation of highly efficient second- and third-order harmonic generation at multiple wavelengths in an x-cut lithium niobate (LN) microdisk resonator. For light waves in the transverse-electric mode propagating along the circumference of the microdisk, the effective nonlinear optical coefficients naturally oscillate periodically to change both the sign and magnitude, facilitating QPM without the necessity of domain engineering in the micrometer-scale LN disk. The second-harmonic and cascaded third-harmonic waves are simultaneously generated with normalized conversion efficiencies as high as 9.9%/mW and 1.05%/mW<sup>2</sup>, respectively, thanks to the utilization of the highest nonlinear coefficient  $d_{33}$  of LN. The high efficiency achieved with the microdisk of a diameter of  $\sim 30 \mu\text{m}$  is beneficial for realizing high-density integration of nonlinear photonic devices such as wavelength converters and entangled photon sources.



0031-9007/19/122(17)/173903(5)

173903-1

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PHYSICAL REVIEW LETTERS 122, 253902 (2019)

## High-Q Exterior Whispering-Gallery Modes in a Double-Layer Crystalline Microdisk Resonator

Yuanlin Zheng,<sup>1,2,\*</sup> Zhiwei Fang,<sup>3,4,5,\*</sup> Shijie Liu,<sup>1,2</sup> Ya Cheng,<sup>3,4,5,6,†</sup> and Xianfeng Chen<sup>1,2,†</sup>

<sup>1</sup>State Key Laboratory of Advanced Optical Communication Systems and Networks, School of Physics and Astronomy, Shanghai Jiao Tong University, Shanghai 200240, China

<sup>2</sup>Key Laboratory for Laser Plasma (Ministry of Education), Collaborative Innovation Center of IFSA, Shanghai Jiao Tong University, Shanghai 200240, China

<sup>3</sup>State Key Laboratory of Precision Spectroscopy, East China Normal University, Shanghai 200062, China

<sup>4</sup>XXL-The Extreme Optoelectromechanics Laboratory, School of Physics and Materials Science, East China Normal University, Shanghai 200241, China

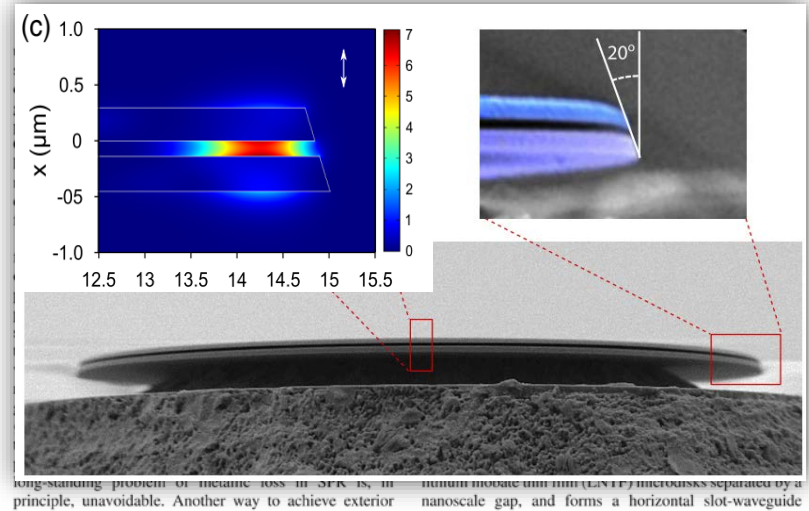
<sup>5</sup>State Key Laboratory of High Field Laser Physics, Shanghai Institute of Optics and Fine Mechanics, Chinese Academy of Sciences, Shanghai 201800, China

<sup>6</sup>Collaborative Innovation Center of Extreme Optics, Shanxi University, Taiyuan, Shanxi 030006, China

(Received 11 April 2019; published 27 June 2019)

Exterior whispering-gallery modes (WGMs), whose mode energy is mainly confined outside the microcavity, can achieve large mode overlapping with the ambient environment, as well as a strong electric field and gradient force at the surface. Here, we demonstrate highly localized WGMs in the nanoair gap of a double-layer crystalline microdisk. The geometry is based on a horizontal slot-waveguide structure of two vertically stacked crystalline microdisks made of lithium niobate thin films. The slot WGM possesses a high quality factor in excess of  $10^5$  without metallic loss. The absorption and scattering loss is reduced by use of the crystalline nanofilm at sub-nm rms surface roughness. The demonstrated configuration can be highly favored in various applications including optical sensing, nonlinear optics, and optomechanics.

DOI: 10.1103/PhysRevLett.122.253902



long-standing problem of metallic loss in SERS is, in lithium niobate thin film (LNLF) microdisks separated by a principle, unavoidable. Another way to achieve exterior nanoscale gap, and forms a horizontal slot-waveguide

0031-9007/19/122(25)/253902(5)

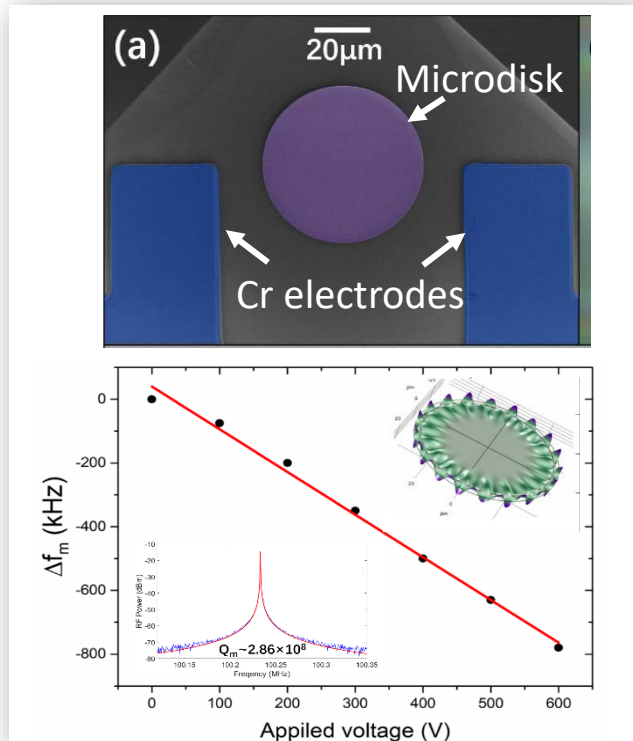
253902-1

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# On-chip electro-optical tunable microresonator

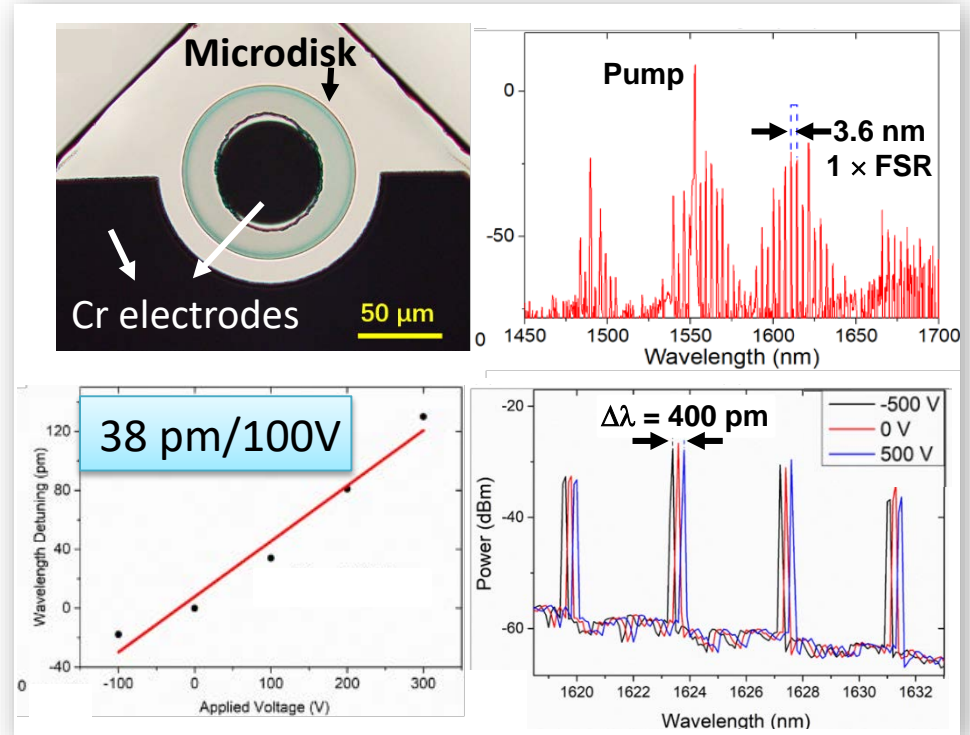
## Tuning of an optical spring



- Optical quality:  $Q \sim 10^7$
- Mechanical quality:  $Q_m \sim 2.86 \times 10^8$
- Electro-mechanical tuning efficiency : -134 kHz/100V

Z. Fang, et al., *Opt. Lett.* 44, 1214 (2019)

## Tuning of an optical frequency comb



- Optical quality  $Q \sim 7.1 \times 10^6$
- The Raman-assisted FWM microcomb: spectral bandwidth of  $\sim 200$  nm
- Electrical tuning efficiency  $\sim 38$  pm/100V

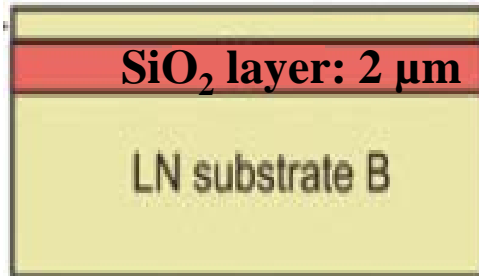
Z. Fang, et al., arXiv preprint arXiv:1909.00399 (2019)

**From laboratory prototype  
to industrial tool:**

***Femtosecond laser assisted chemo-  
mechanical polish lithography***

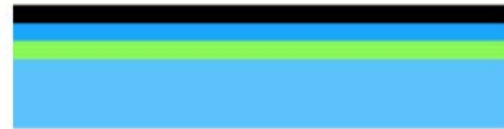
# Fabrication of low-loss LN waveguides

LN thin film: 700 nm



Laser Photon Rev. 6,  
488 (2012)

(a) Cr deposition



(b) Femtosecond laser ablation



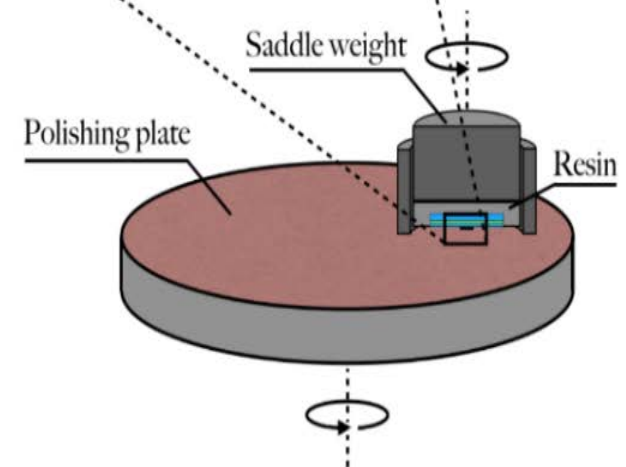
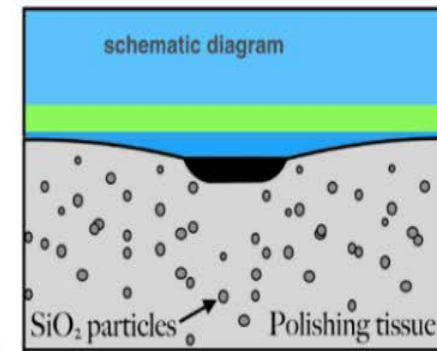
(c) Chemical Mechanical Polishing (CMP)



(d) Cr removal and secondary CMP

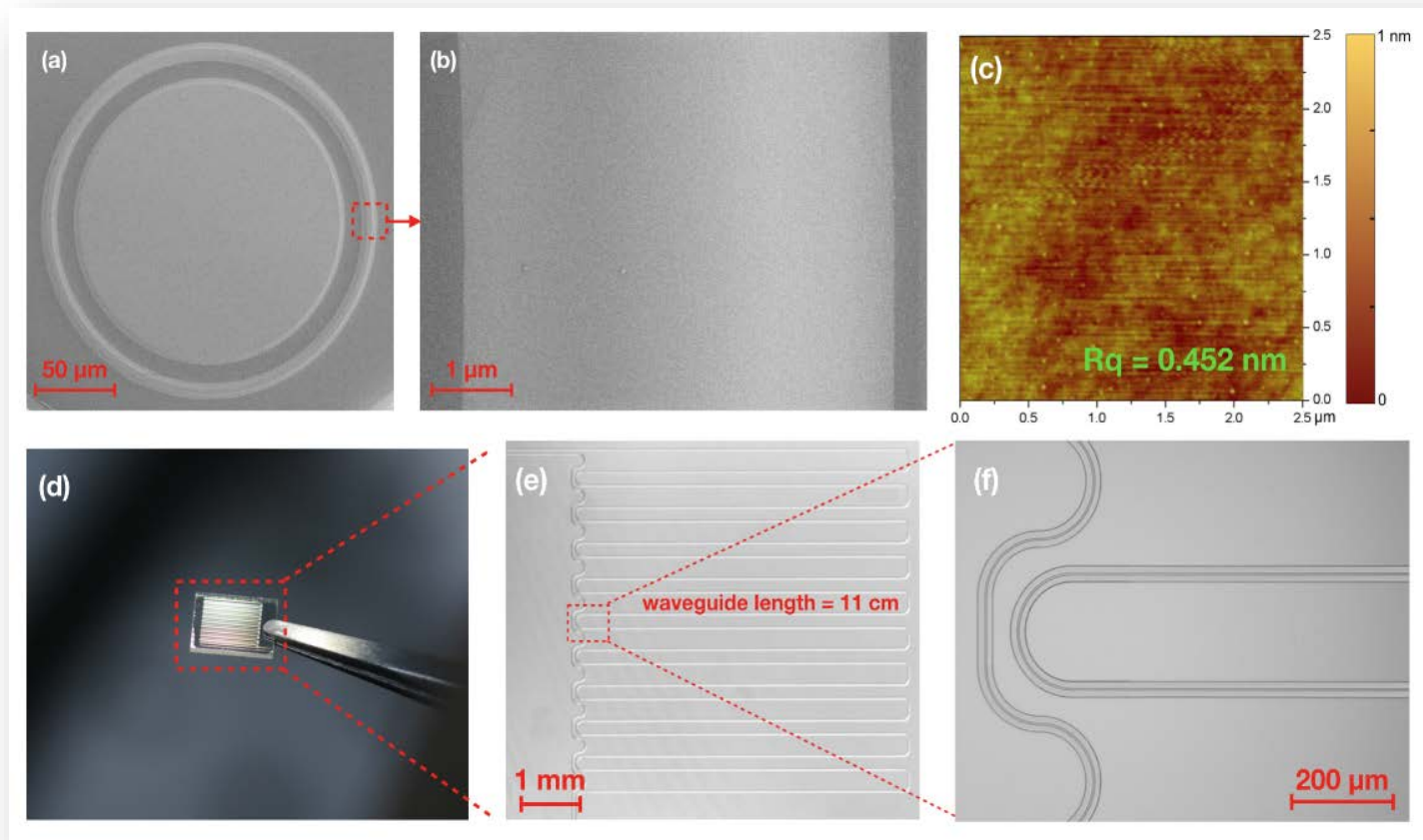


(e) Schematic diagram of CMP



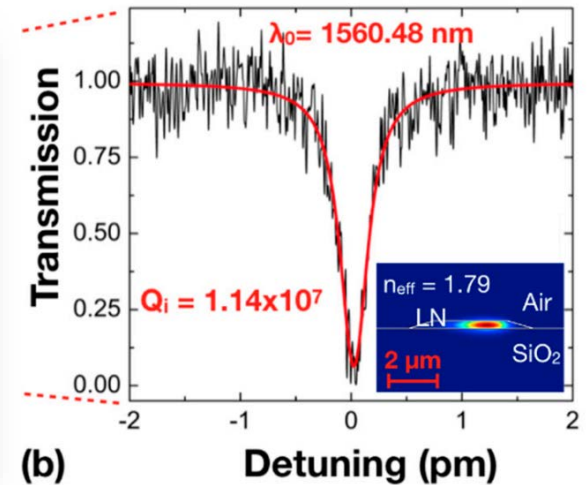
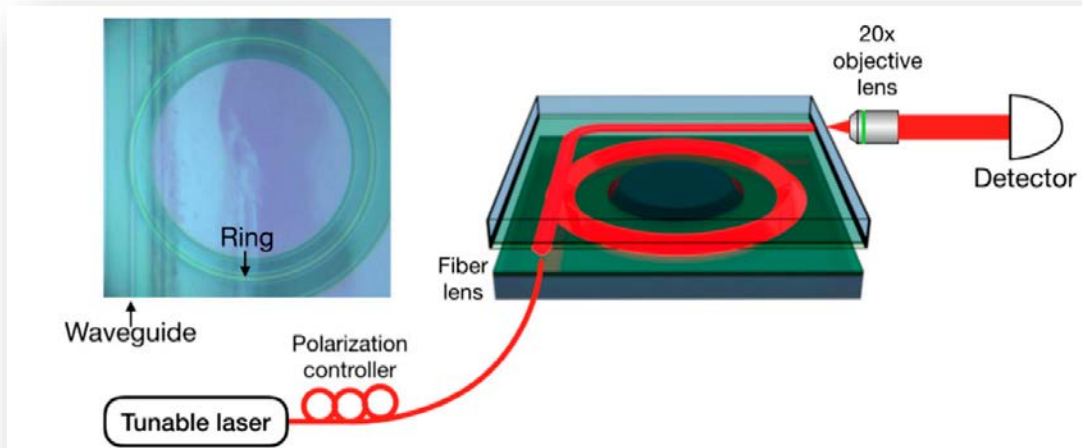
Ya Cheng et al. Patent No: 201810407783.3; US patent No: 16404735  
R. B. Wu, et al, Nanomaterials 8, 910 (2018)

# Fabrication of low-loss LN waveguides



**Keypoint:** extremely smooth surface with a surface roughness as low as 0.452 nm.

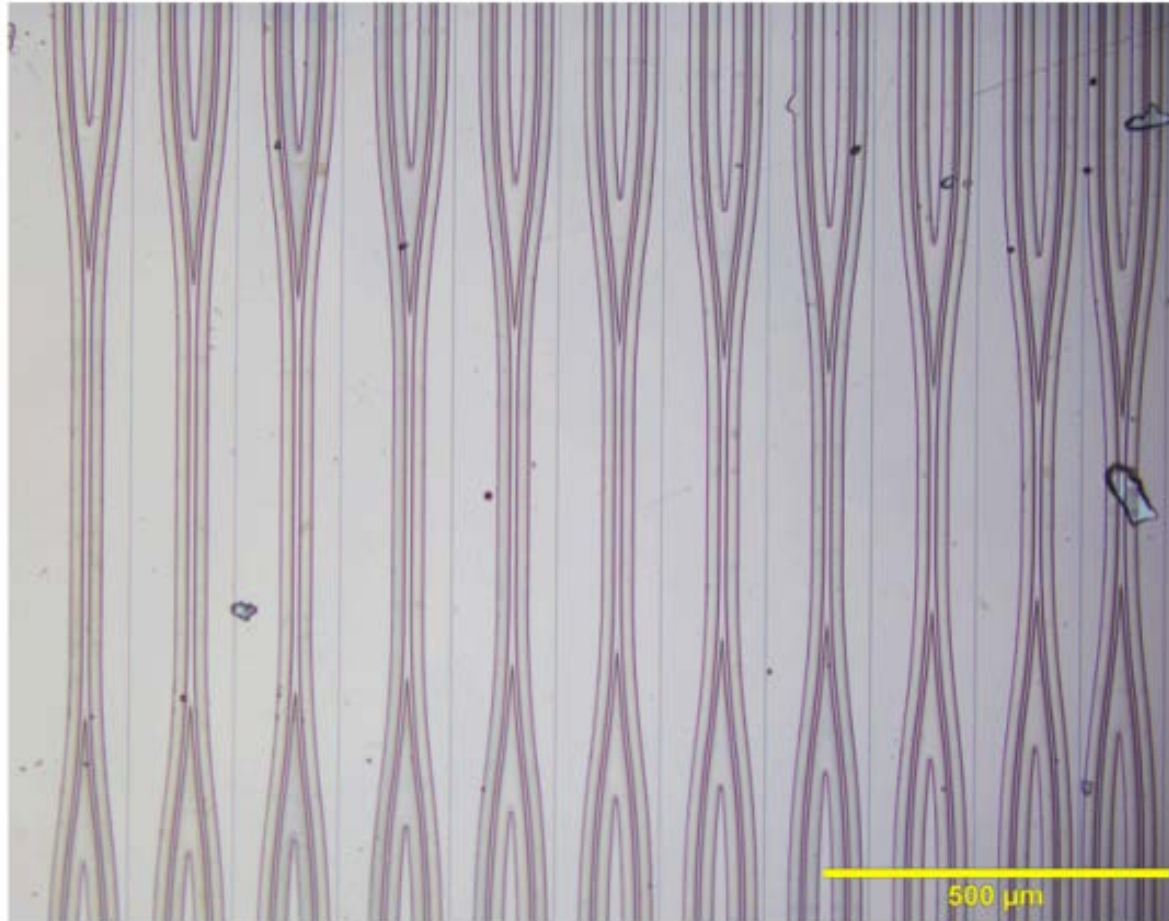
# Propagation loss measurement



$$\alpha = \frac{2\pi n_{\text{eff}}}{Q\lambda} = 0.027 \text{ dB/cm}$$

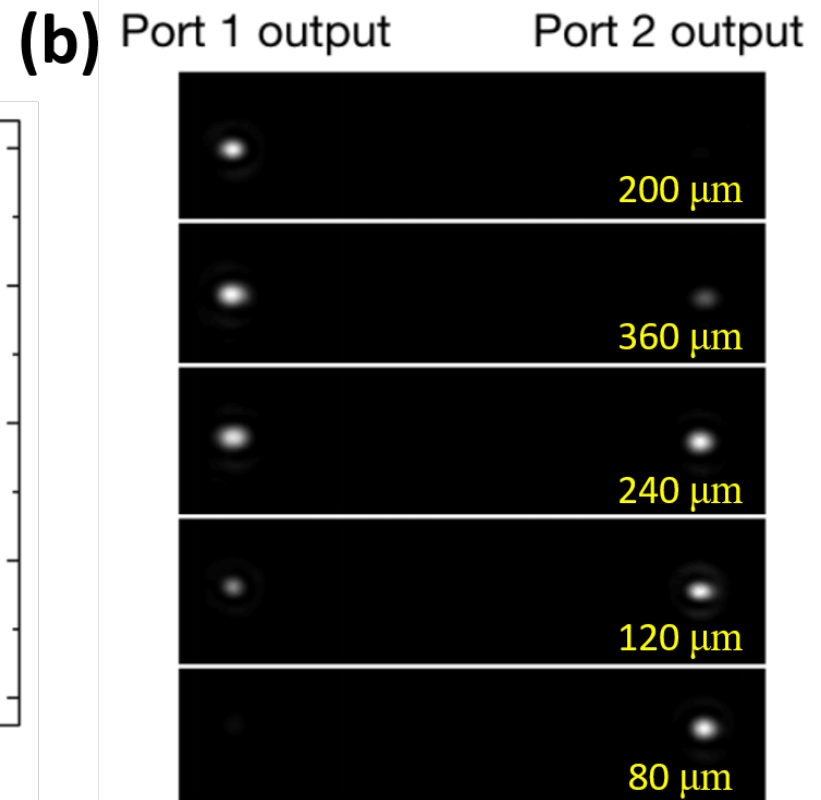
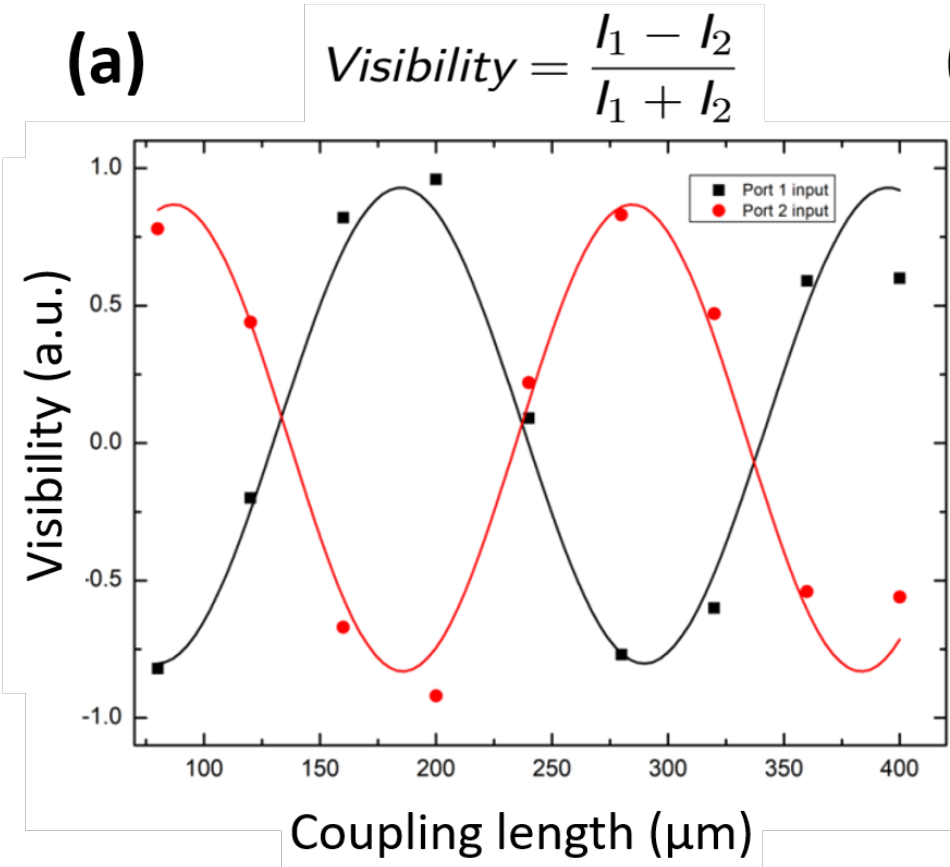
Loss measurement via measurement of Q factor of a waveguide ring resonator: **loss 0.027 dB/cm.**

# Beamsplitters built by LNOI waveguides



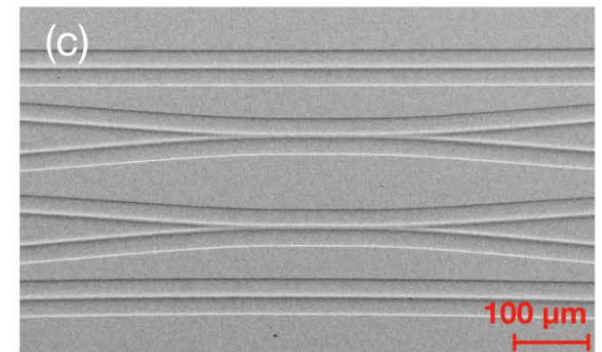
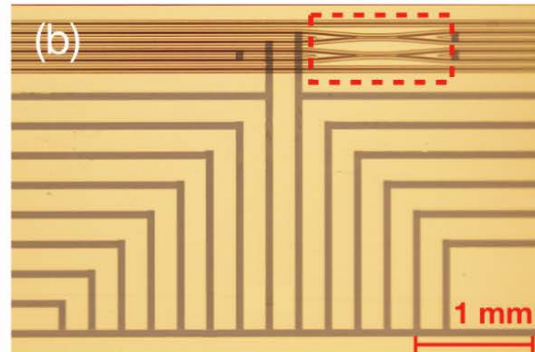
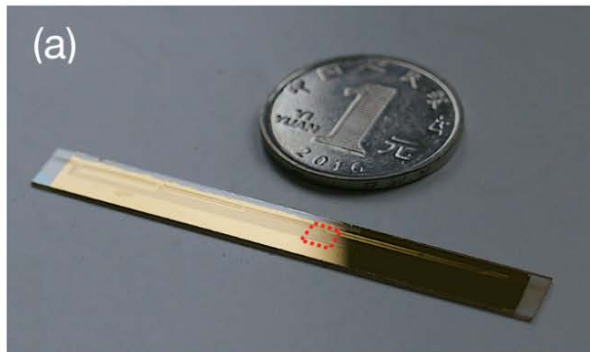
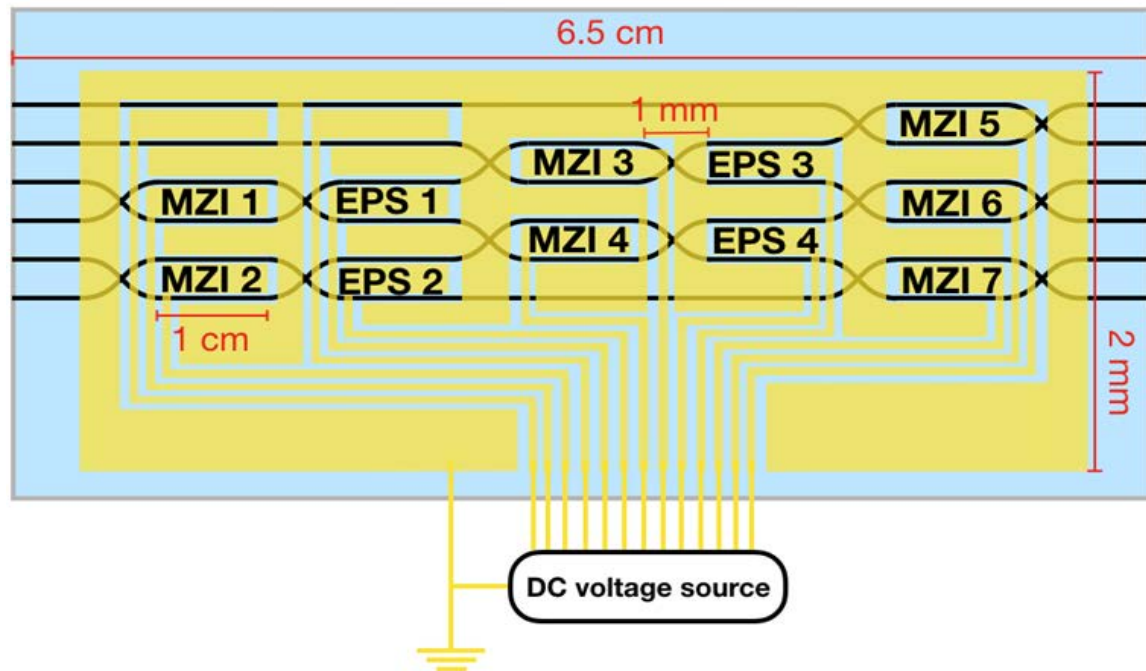
M. Wang, R. Wu, J. Lin, et al. *Quantum Engineering* e9, 1 (2019).

# Beamsplitters built by LNOI waveguides



M. Wang, R. Wu, J. Lin, et al. Quantum Engineering e9, 1 (2019).

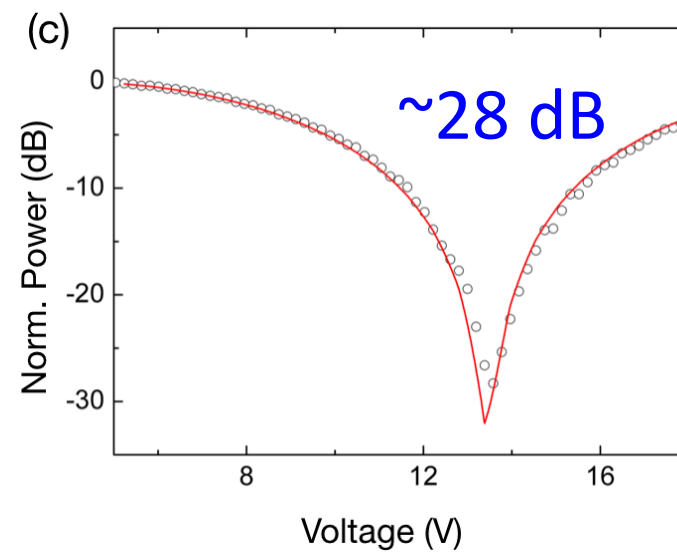
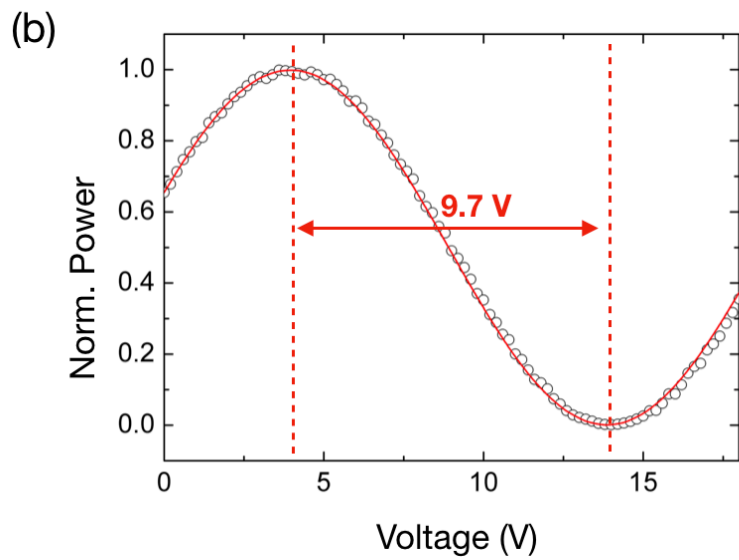
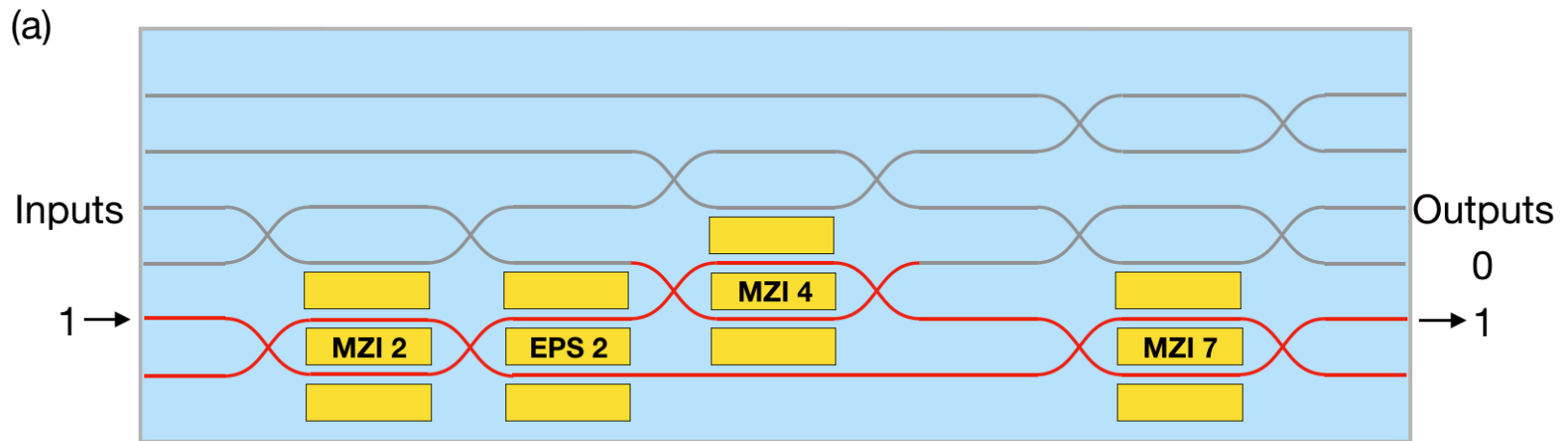
# A multifunctional photonic chip on LNOI



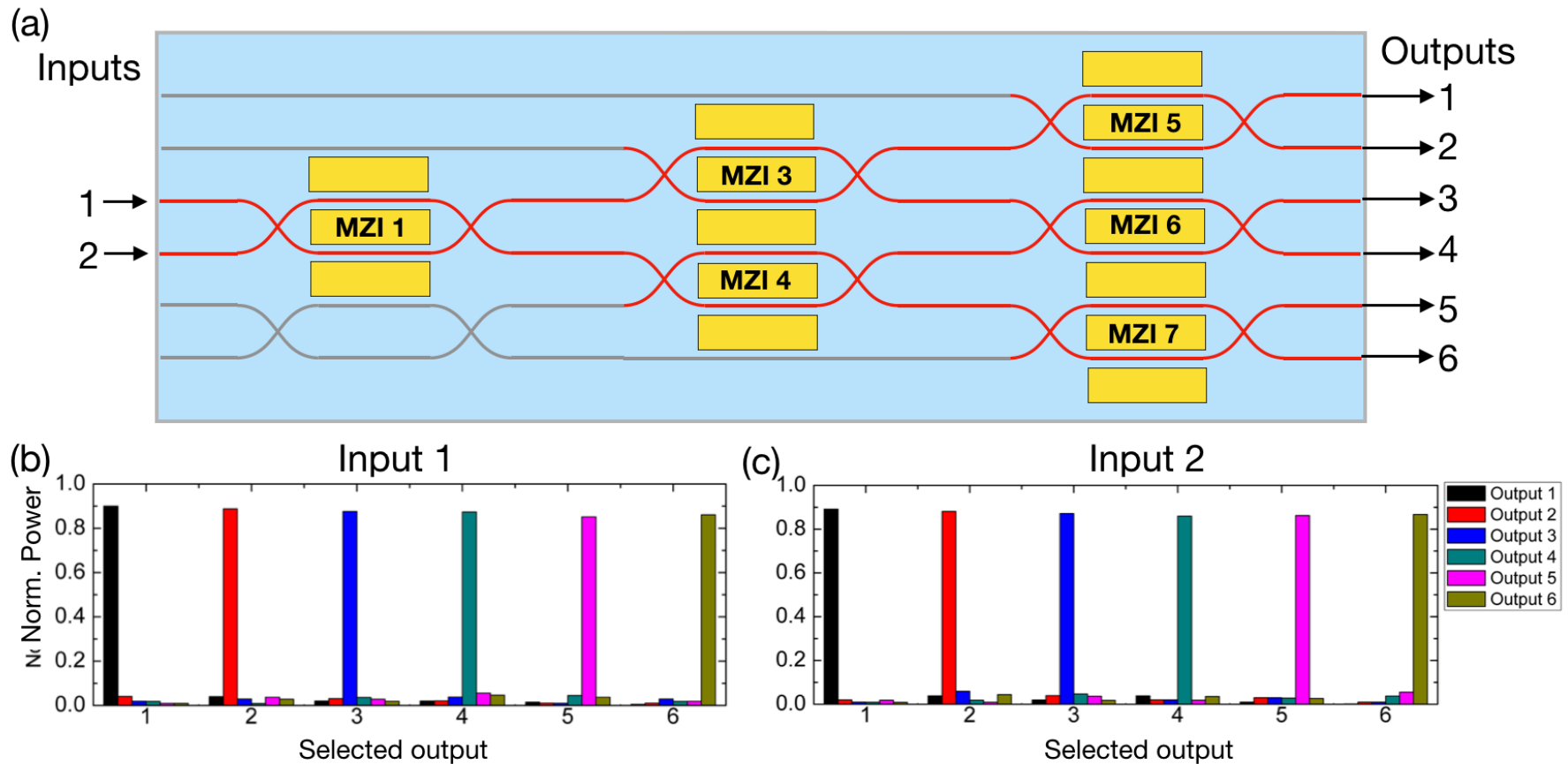
R. Wu, J. Lin, M. Wang, et. al. Opt. Lett. 44, 4698 (2019)



# A perfect beamsplitter of tunable ratio

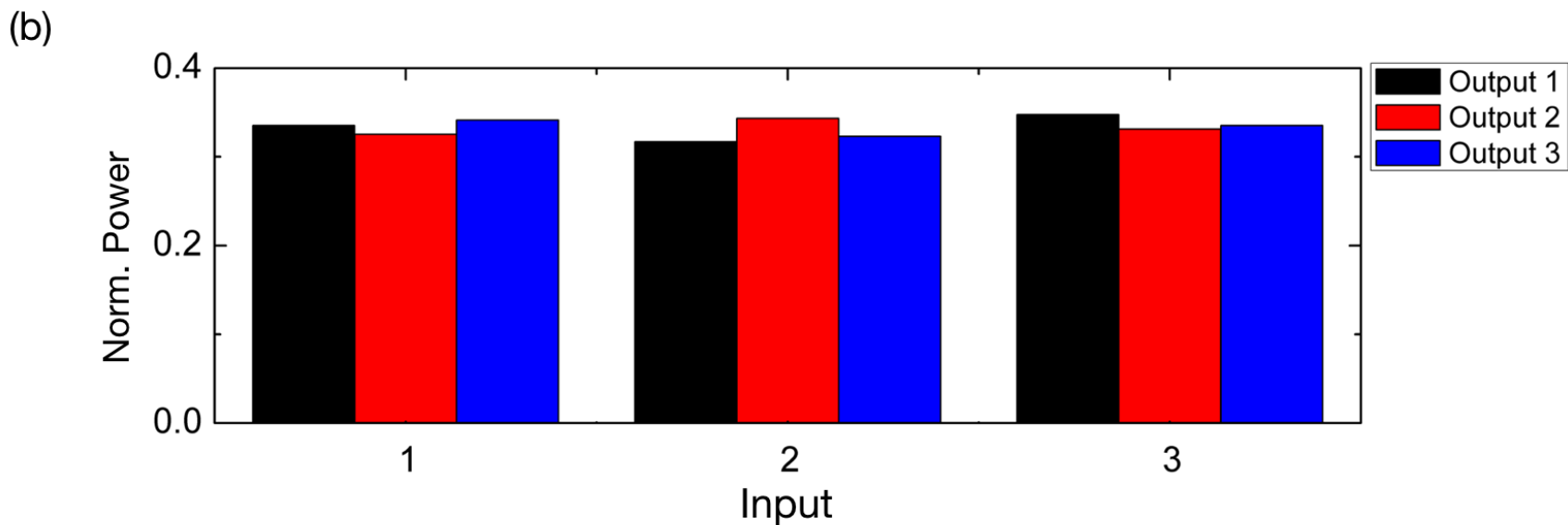
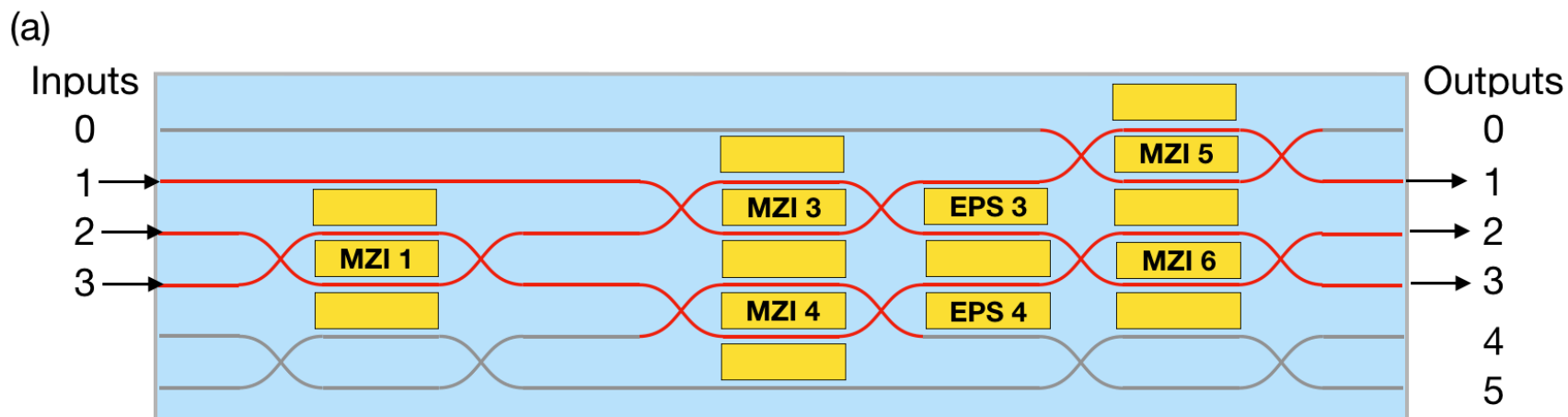


# Demonstration of 1 x 6 optical switch



R. Wu, J. Lin, M. Wang, et. al. Opt. Lett. 44, 4698 (2019)

# A balanced 3 x 3 interferometer



# Conclusions

For the first times, we demonstrate:

1. Aberration free focusing deeply into glass;
2. Centimeter-scale microfluidic systems fabricated with high-throughput internal processing;
3. Lithium niobate waveguides of a propagation loss  $\sim 0.02$  dB/cm !

**Together, revolutionary products can be created in a profitable fashion!**

# You can buy the fluidic and photonic devices



華東師範大學  
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极端光机电实验室

XXL-THE eXTREME OPTOELECTROMECHANIX LABORATORY

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Micromachines 10, 565 (2019)  
<https://doi.org/10.3390/mi10090565>

## We are producing:

- **lithium niobate microresonators** ( $Q > 10^7$ ),
- **lithium niobate waveguides** (loss:  $< 0.05$  dB/cm, length: up to tens of centimeters),
- **customer-designed microfluidics** (channel diameters: from  $\sim 1$   $\mu\text{m}$  to  $\sim 1$  mm; channel length: up to  $\sim 1$  m).

Prices are negotiable. Free samples are available under the condition of collaboration.

Contact us or place your order by sending your emails to

[xxl@phy.ecnu.edu.cn](mailto:xxl@phy.ecnu.edu.cn)

Please visit: [xxl.ecnu.edu.cn](http://xxl.ecnu.edu.cn)